

**TOTAL IONIZATION DOSE TEST REPORT***No. 99T-RT14100-72**J. J. Wang**(408)522-4576**[jih-jong.wang@actel.com](mailto:jih-jong.wang@actel.com)***1.0 SUMMARY TABLE**

A14100A Parametrics/Characteristics	Results
1. Functionality	Not tested to the limit, Passed 20krad(Si)
2. $I_{DDSTDBY}$	Passed 20krad(Si) (Figure)
3. $V_{IL}/V_{IH}$	Passed 20krad(Si)
4. $V_{OL}/V_{OH}$	Passed 20krad(Si)
5. Propagation Delays	Passed 20krad(Si)
6. Rising/Falling Edge Transient	Passed 20krad(Si)
7. Startup Transient Current	Passed 20krad(Si) (Figures )

**2.0 TID TEST**

This section describes the device under test (DUT), the irradiation parameters, and the testing method.

**2.1 TEST DEVICE**

Table 1 lists the DUT information.

Table 1. DUT Information

Part Number	RT14100A
Package	CQFP256
Foundry	MEC
Technology	0.8 $\mu$ m CMOS
Die Lot Number	UCL072
Quantity Tested	5
Serial Numbers	LAN905 (control), LAN2001, LAN2002, LAN2003, LAN2004

**2.2 IRRADIATION**

Table 2 lists the irradiation parameters.

Table 2. Irradiation Parameters

Facility	NASA
Radiation Source	Co-60
Dose Rate	6krad(Si)/day (+-10%)
Final Total Dose	20krad(Si)
Temperature	Room
Bias	5V

## 2.3 TEST METHOD

The test method is in compliance with TM1019. It uses the biased room-temperature anneal to simulate the extremely slow-dose-rate space environment. Figure 1 shows the process flow. Rebound annealing at 100°C is omitted because there are enough data showing antifuse FPGAs fabricated in MEC foundry have no rebound effects (see, for example, the recent TID Report No. 98-T14100-2).

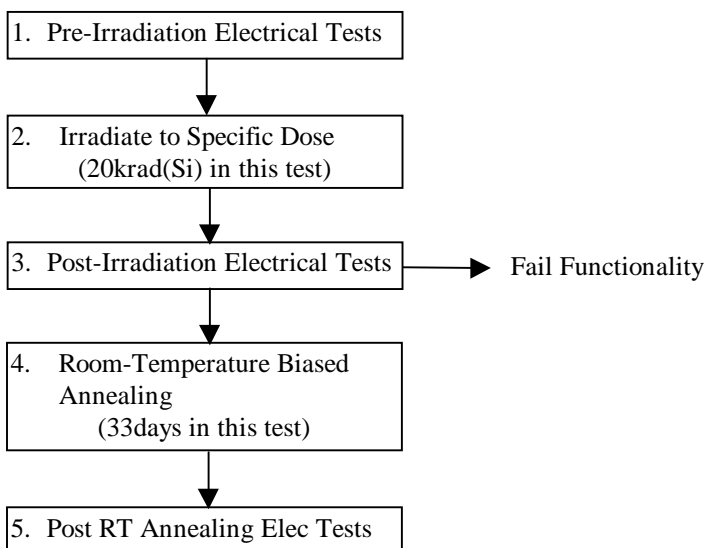


Figure 1. Test method flow chart.

## 2.4 ELECTRICAL PARAMETERS/CHARACTERISTICS TESTS

The electrical parameters/characteristics were measured on the bench. Compared to an automatic tester, this bench setup has much lower noise. For AC/DC characteristics measurement, the automatic tester can measure every possible pin while the bench setup only samples few pins (due to logistics, not inability). However, since the total dose tolerance is always limited by the  $I_{DDstandby}$ , not by AC/DC characteristics, sampling pins for AC/DC characteristics should be enough. Also,  $I_{DDstandby}$  is best measured by a bench setup. For example, the in-situ monitoring during irradiation done in this report is logistically impossible for an automatic tester. An important but non-standard parameter, startup transient current, basically can only be measured on the bench too. The corresponding logic design circuit for each test parameter is listed in Table 3.

Table 3. Logic Design for each Measured Parameter/Characteristic

Parameter/Characteristics	Logic Design
1. Functionality	All key architectural functions
2. $I_{DDSTDBY}$	DUT power supply
3. $V_{IL}/V_{IH}$	TTL compatible input buffer
4. $V_{OL}/V_{OH}$	TTL compatible output buffer
5. Propagation Delays	String of inverters
6. Rising/Falling Edge	D flip-flop output

**3.0 TEST RESULTS**

This section presents all the parameter/characteristic results for pre-irradiation (step 1 in Figure 1), post-irradiation (step 3), and post room temperature anneal tests (step 5).

**3.1 FUNCTIONAL TEST**

Table 4 lists the functional test results.

Table 4. Functionality Test Results

	Pre-Irradiation	Post-Irradiation	Post-Anneal
LAN905 (cntl)	passed	passed	passed
LAN2001	passed	passed	passed
LAN2002	passed	passed	passed
LAN2003	passed	passed	passed
LAN2004	passed	passed	passed

**3.2 IDDSTANDBY**

$I_{DDstandby}$  (labeled  $I_{CC}$  in some Figures) was monitored during the irradiation and room-temperature anneal. The delta  $I_{DDstandby}$  is the increment  $I_{DDstandby}$  due to irradiation/anneal effect. Compared to the spec of 25mA, the small (< 1mA) pre-irradiation  $I_{DDstandby}$  is negligible. Thus the delta  $I_{DDstandby}$  spec is approximately 25mA.

As shown in Figure 2, four DUTs, LAN2001, LAN2002, LAN2003 and LAN2004 were irradiation to just over 20krad(Si). The worst case is LAN2003, with final  $I_{DDstandby} \sim 29$ mA. Since all DUTs passed post-irradiation functional test, per TM1019, room temperature,  $V_{CC}$  (5V) biased annealing can be performed to reduce the leakage current ( $I_{DDstandby}$ ). Figure 2 shows the reduction of leakage with respect to annealing time. After 33 days anneal, all DUTs have  $I_{DDstandby}$  no more than 3mA.

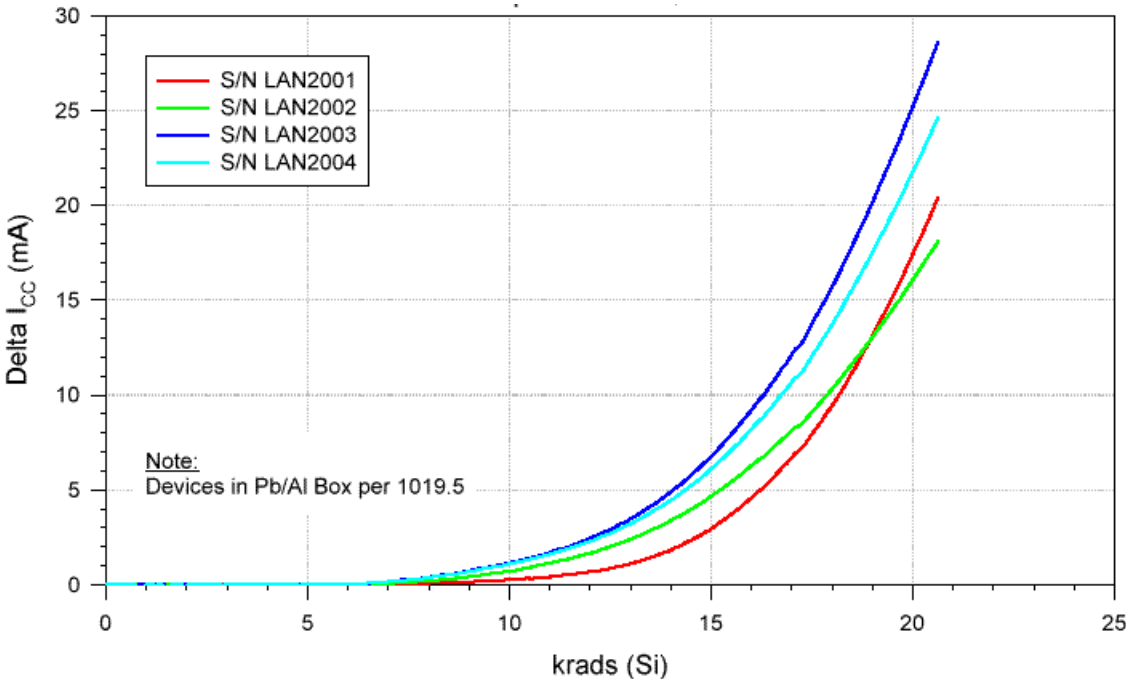


Figure 2. Delta  $I_{DDstandby}$  versus total cumulative dose.

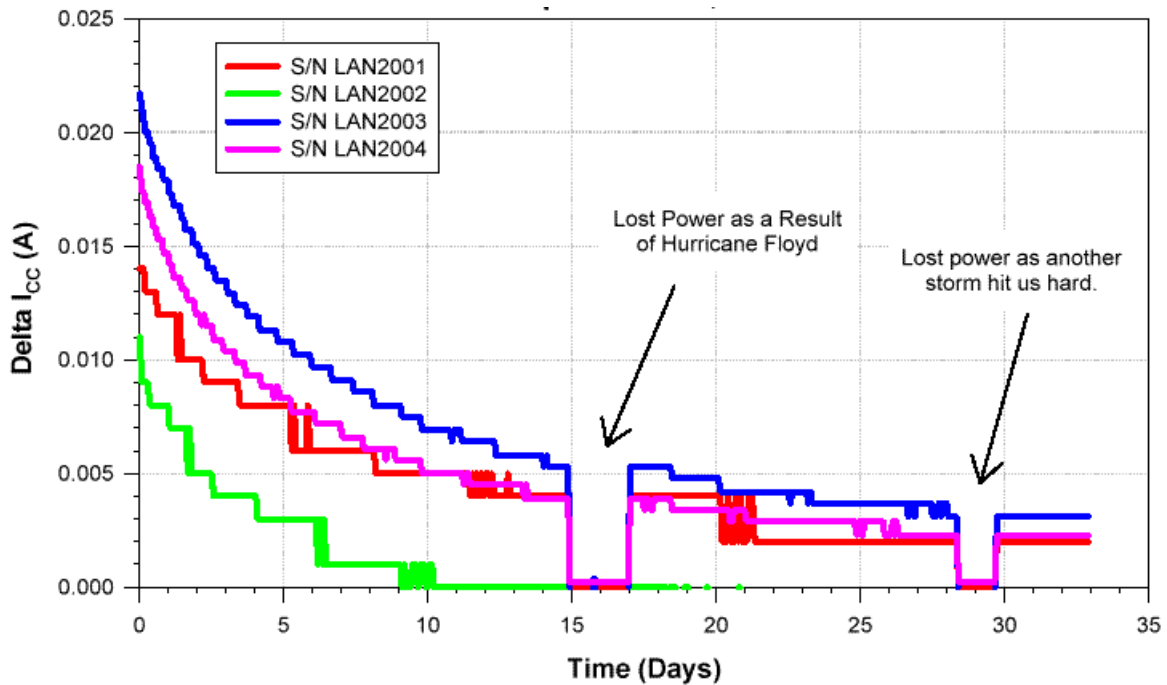


Figure 3. Showing the reduction of  $I_{DD\text{standby}}$  by room temperature annealing.

### 3.3 INPUT LOGIC THRESHOLD

Table 5 lists the input logic threshold of each DUT for pre-irradiation, post-irradiation and post room-temperature anneal test.

Table 5. Input Logic Threshold ( $V_{IL}/V_{IH}$ ) Results

	Pre-Irradiation	Post-Irradiation	Post-Anneal
LAN905 (cntl)	1.19V	1.19V	1.25V
LAN2001	1.19V	1.21V	1.29V
LAN2002	1.19V	1.20V	1.27V
LAN2003	1.19V	1.21V	1.28V
LAN2004	1.17V	1.20V	1.27V

### 3.4 OUTPUT CHARACTERISTIC

Figure 4a and 4b show the  $V_{OL}$  characteristic curve for pre-irradiation and post-irradiation respectively. For each DUT, both pre- and post-irradiation test passed the spec, and no significant radiation effect can be identified. For the reference, the spec is, at  $I_{OL} = 6\text{mA}$ ,  $V_{OL}$  cannot exceed 0.4V.

Figure 5a and 5b show the  $V_{OH}$  characteristic curve for pre-irradiation and post-irradiation respectively. For each DUT, both pre- and post-irradiation test passed the spec, and the radiation effect is negligible. The spec is, at  $I_{OH} = 4\text{mA}$ ,  $V_{OH}$  cannot be lower than 3.7V.

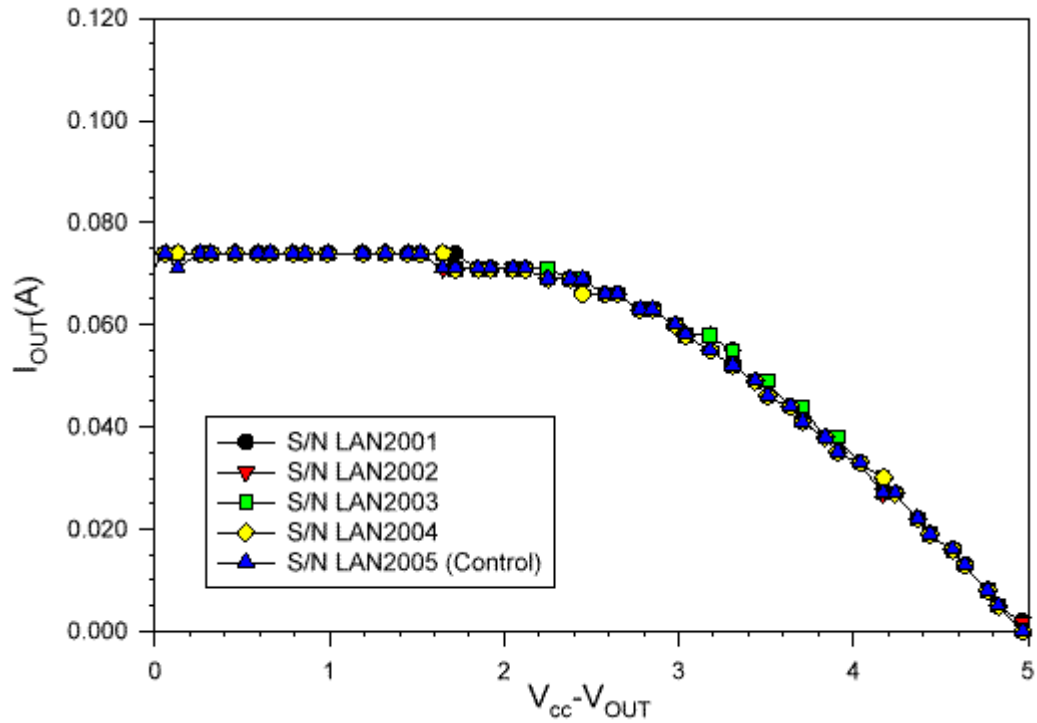


Figure 4a. Pre-irradiation  $V_{OL}$  characteristic curve.

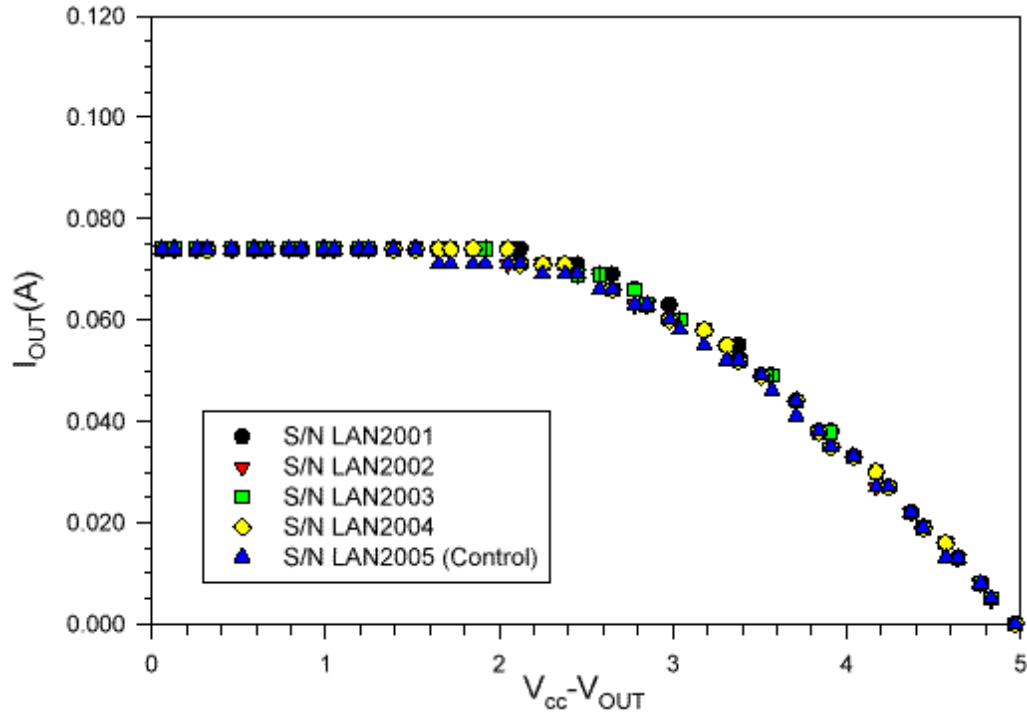


Figure 4b. Post-irradiation  $V_{OL}$  characteristic curve.

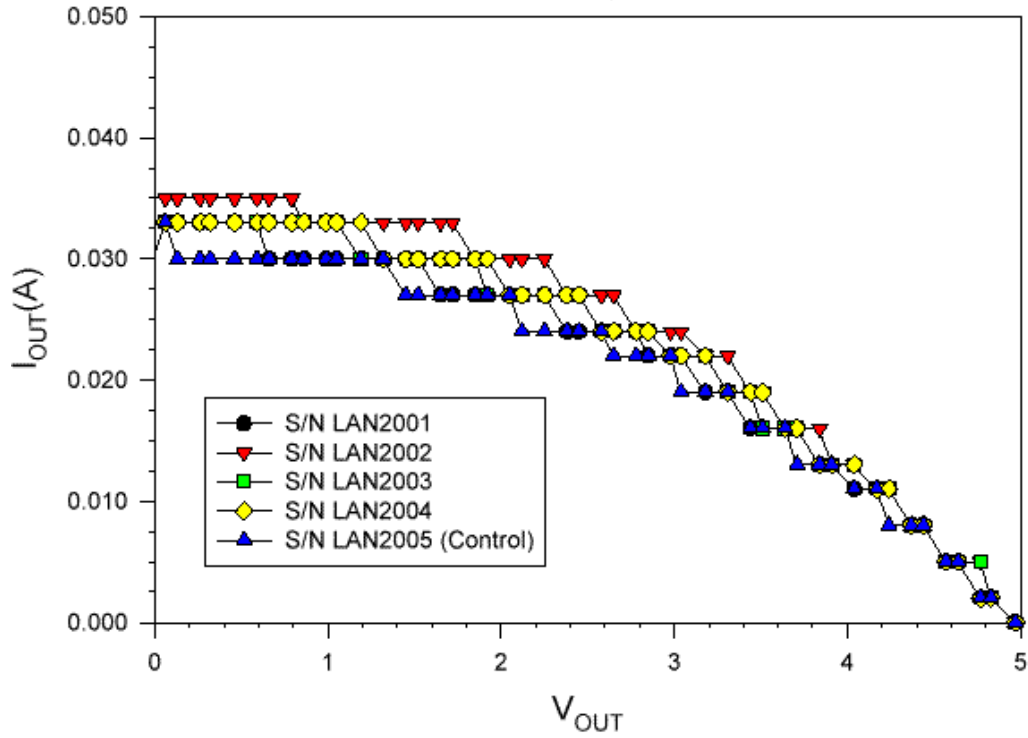


Figure 5a. Pre-irradiation  $V_{OH}$  characteristic curve

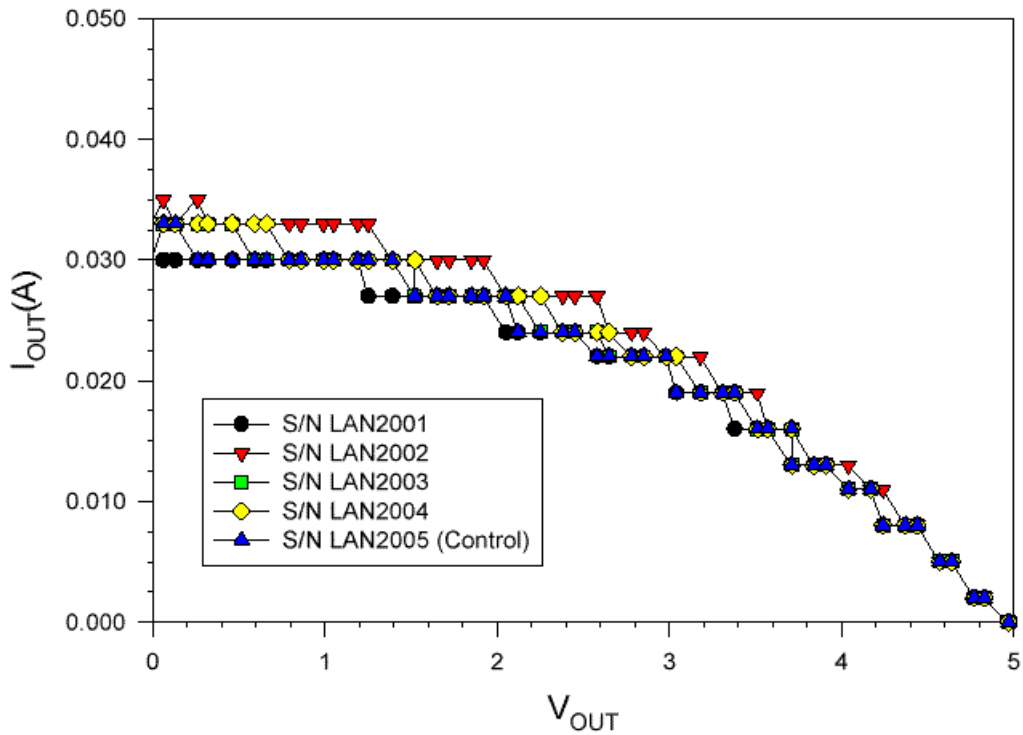


Figure 5b. Post-irradiation  $V_{OH}$  characteristic curve

### **3.5 PROPAGATION DELAYS**

Three types of propagation delays were measured, a combinational logic, the clock to Q delay of a serial-in shift register, and the clock to Q of a serial-out shift register. The rising edge and falling edge were measured separately. The following Table 6, 7 and 8 list the results. The variation due to irradiation/annealing effect is always well within 10%.

Table 6. Propagation Delay of Combinational Logic (ns)

	Rising Output			Falling Output		
	Pre-Irradiation	Post-Irradiation	Post-Anneal	Pre-Irradiation	Post-Irradiation	Post-Anneal
LAN905(cntl)	934	926	932	933	925	931
LAN2001	938	967	950	937	953	939
LAN2002	899	899	905	897	886	895
LAN2003	920	933	930	919	920	921
LAN2004	914	926	928	913	914	918

Table 7. Clock to Q Delay of Serial-In Shift Register (ns)

	Rising Output			Falling Output		
	Pre-Irradiation	Post-Irradiation	Post-Anneal	Pre-Irradiation	Post-Irradiation	Post-Anneal
LAN905(cntl)	9.5	9.5	9.8	9.6	9.4	9.8
LAN2001	9.6	9.6	10.1	9.7	9.8	10.3
LAN2002	10.2	9.3	9.7	9.8	9.7	9.9
LAN2003	10.4	9.9	10.0	10.4	10.1	10.2
LAN2004	10.2	9.8	9.8	10.3	9.9	10.1

Table 8. Clock to Q Delay of Serial Out Shift Register (ns)

	Rising Output			Falling Output		
	Pre-Irradiation	Post-Irradiation	Post-Anneal	Pre-Irradiation	Post-Irradiation	Post-Anneal
LAN905(cntl)	5.7	6.2	6.4	5.4	5.4	5.8
LAN2001	6.0	6.2	6.5	5.5	5.7	5.8
LAN2002	6.3	5.3	6.1	5.9	5.0	5.5
LAN2003	6.5	6.3	6.4	5.9	5.6	5.8
LAN2004	6.7	6.0	6.3	6.1	5.3	5.7

### **3.6 RISING/FALLING EDGE TRANSIENT**

The rising and falling edge transient of the output of a D flip-flop in the DUT were measured pre-irradiation, post-irradiation, and post-anneal. Figures 6-10 show the rising edge transient. Figures 11-15 show the falling edge transient. The irradiation/annealing effect is basically negligible.

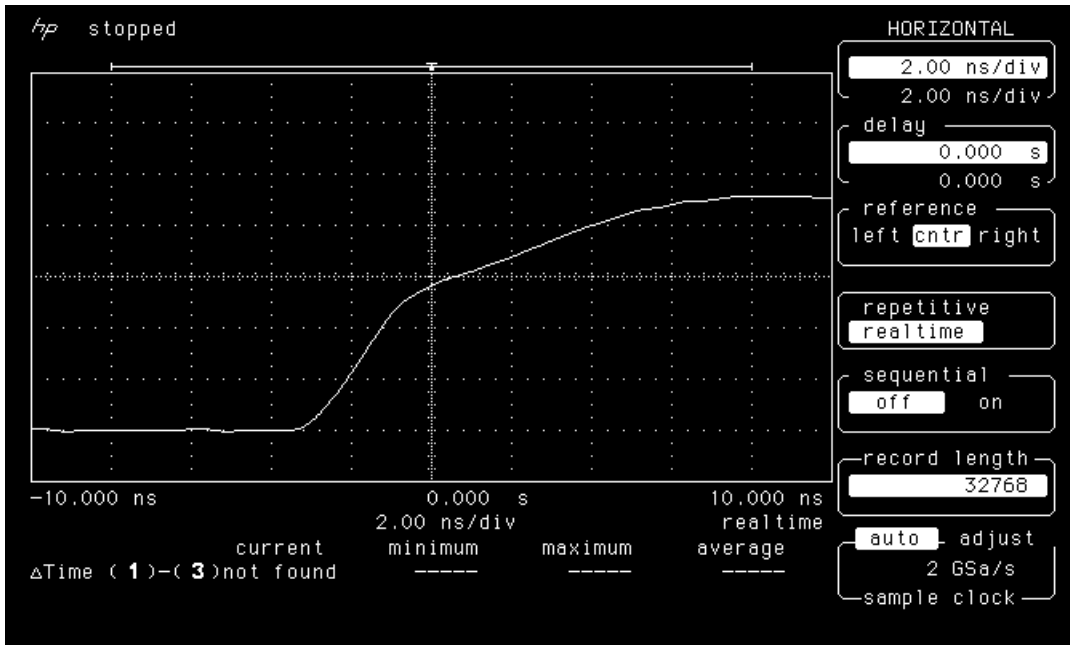


Figure 6a. Rising edge of LAN905 (control) measured with pre-irradiation DUTs.

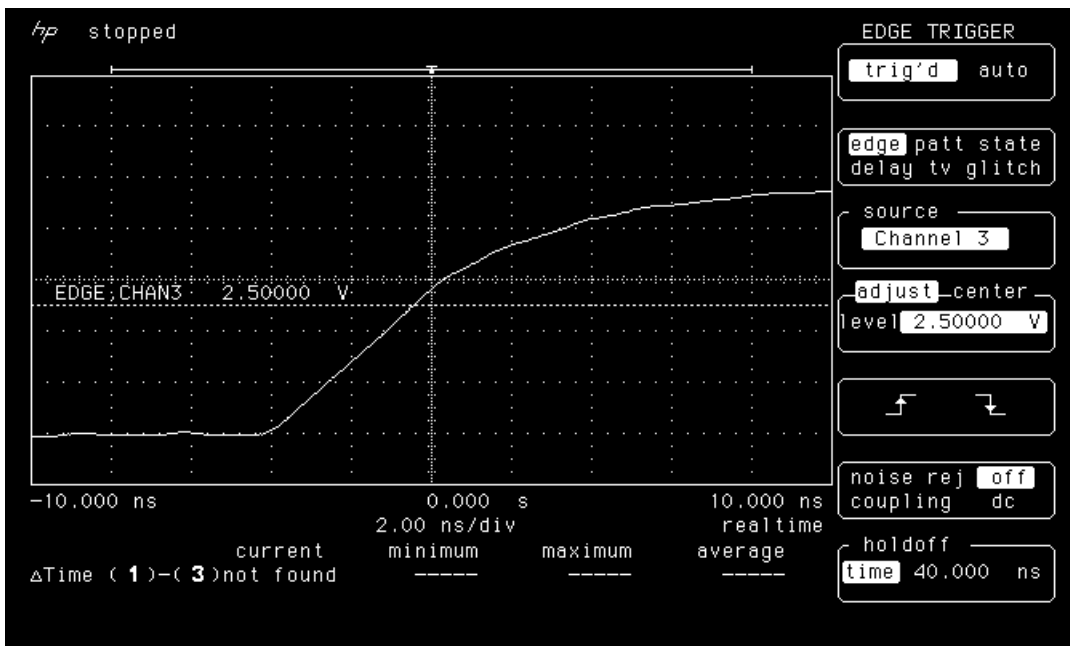


Figure 6b. Rising edge of LAN905 (control) measured with post-irradiation DUTs.



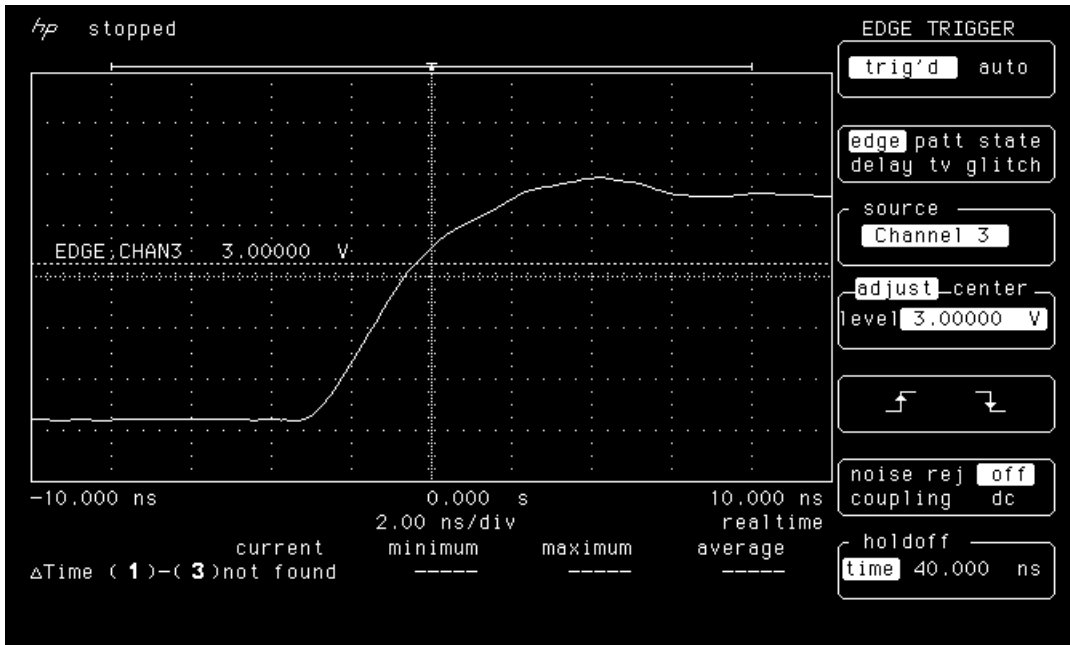


Figure 6c. Rising edge of LAN905 (control) measured with post-anneal DUTs.

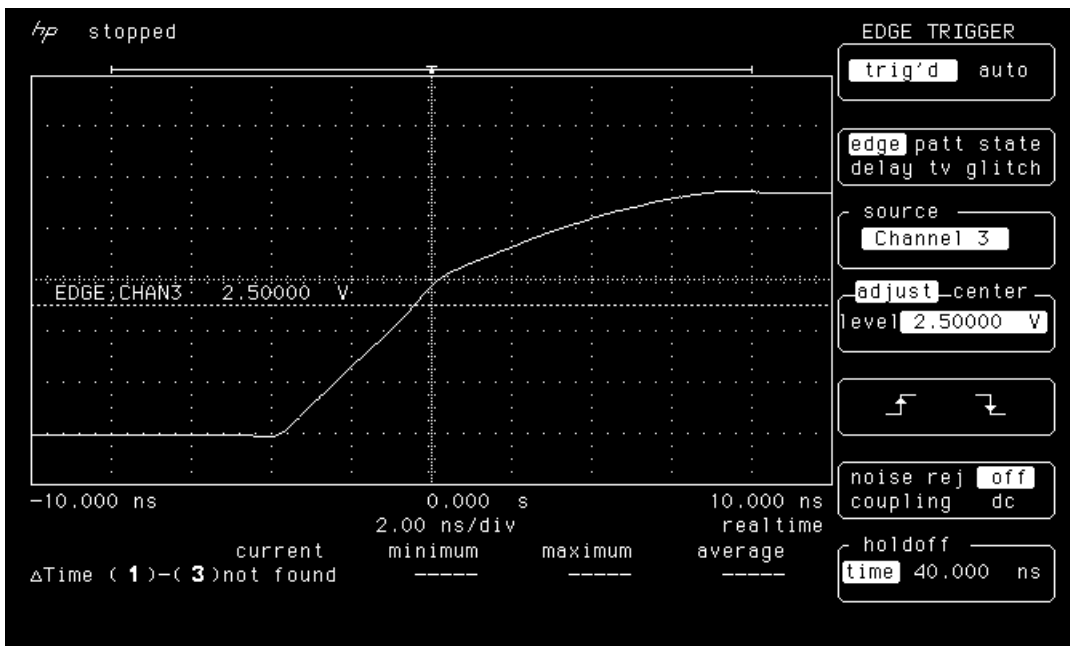


Figure 7a. Rising edge of LAN2001 pre-irradiation.

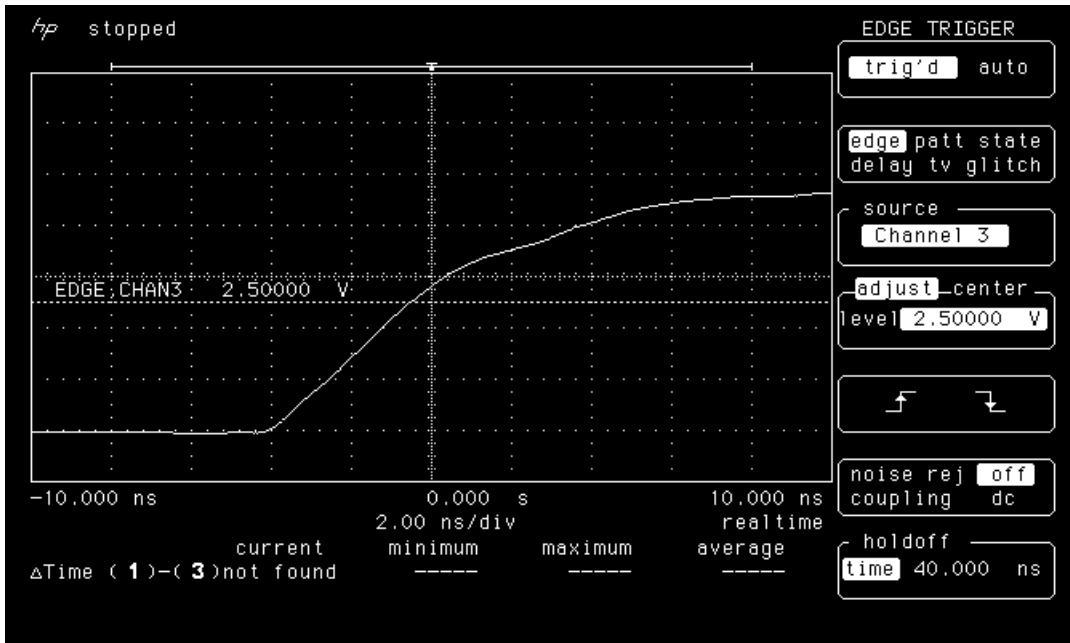


Figure 7b. Rising edge of LAN2001 post-irradiation.

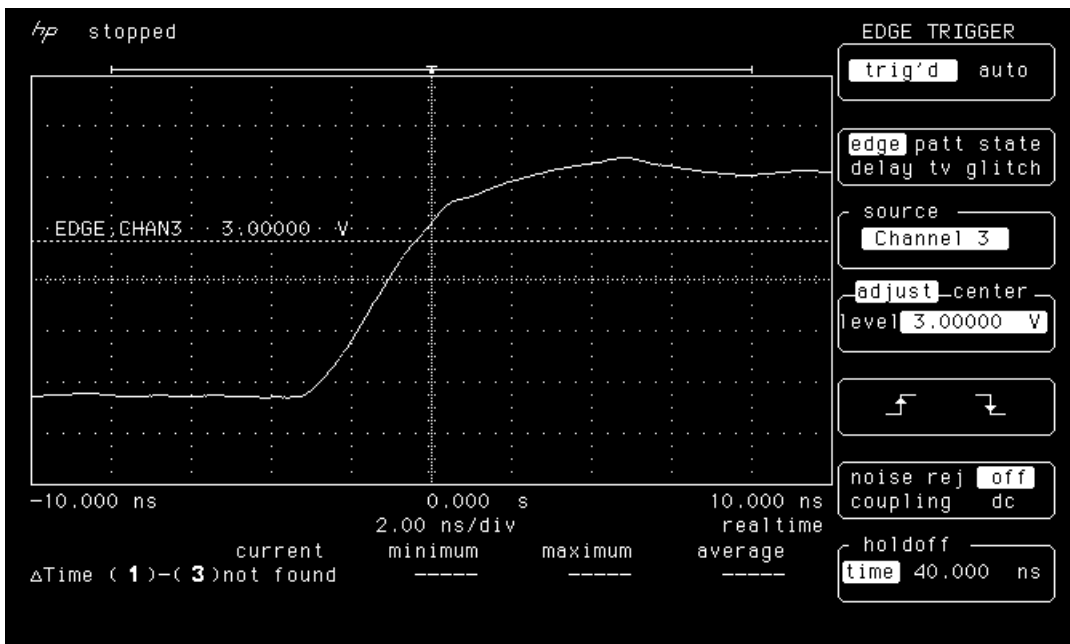


Figure 7c. Rising edge of LAN2001 post-anneal.

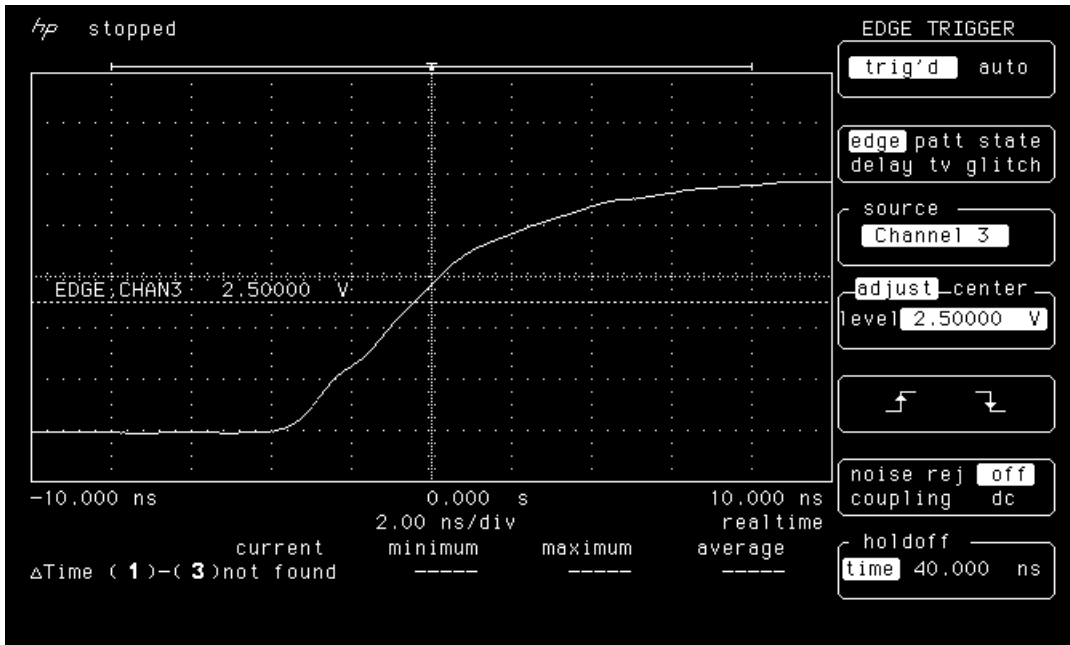


Figure 8a. Rising edge of LAN2002 pre-irradiation.

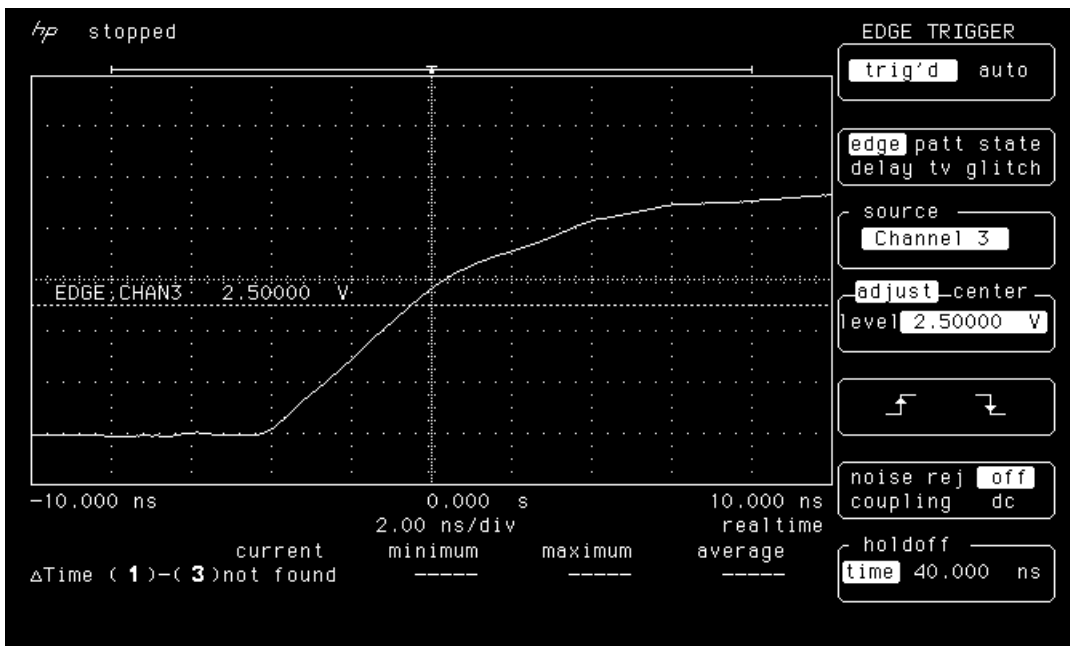


Figure 8b. Rising edge of LAN2002 post-irradiation.

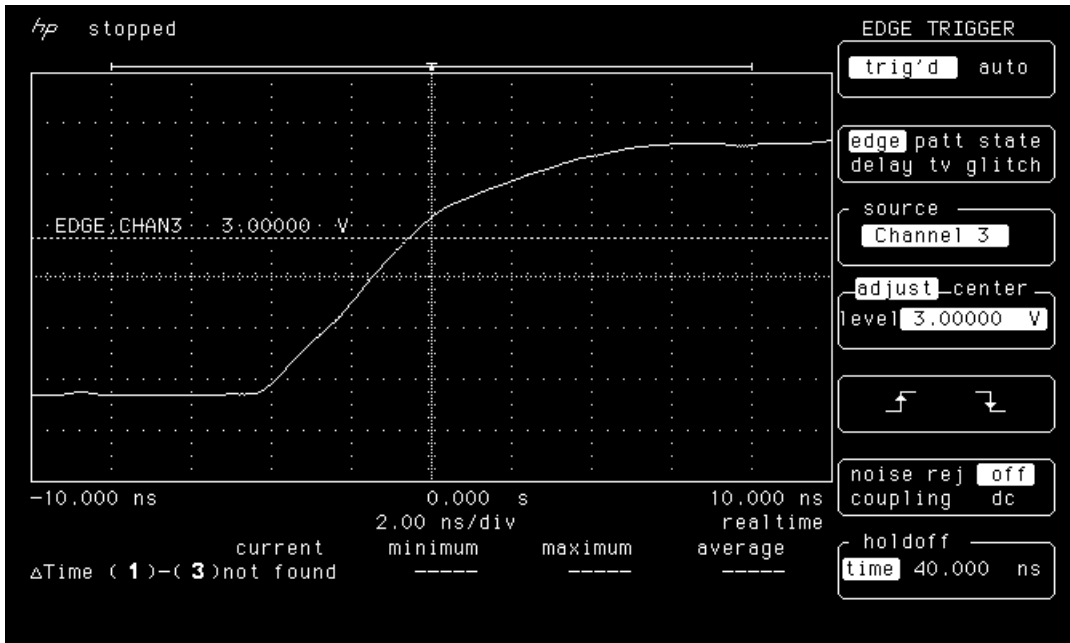


Figure 8c. Rising edge of LAN2002 post-anneal.

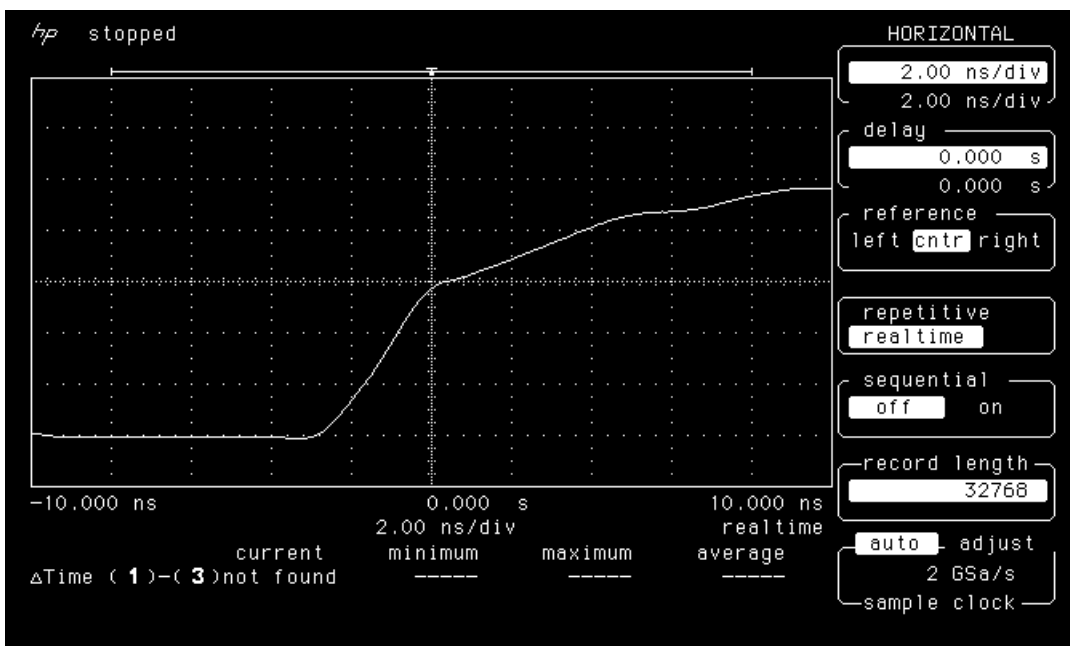


Figure 9a. Rising edge of LAN2003 pre-irradiation

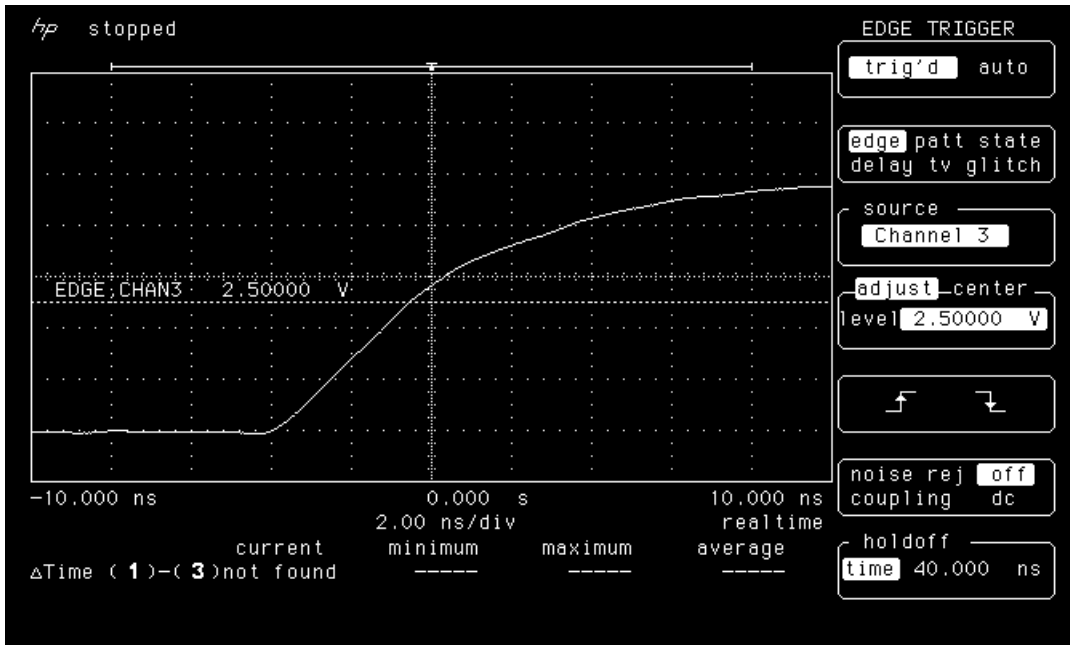


Figure 9b. Rising edge of LAN203 post-irradiation

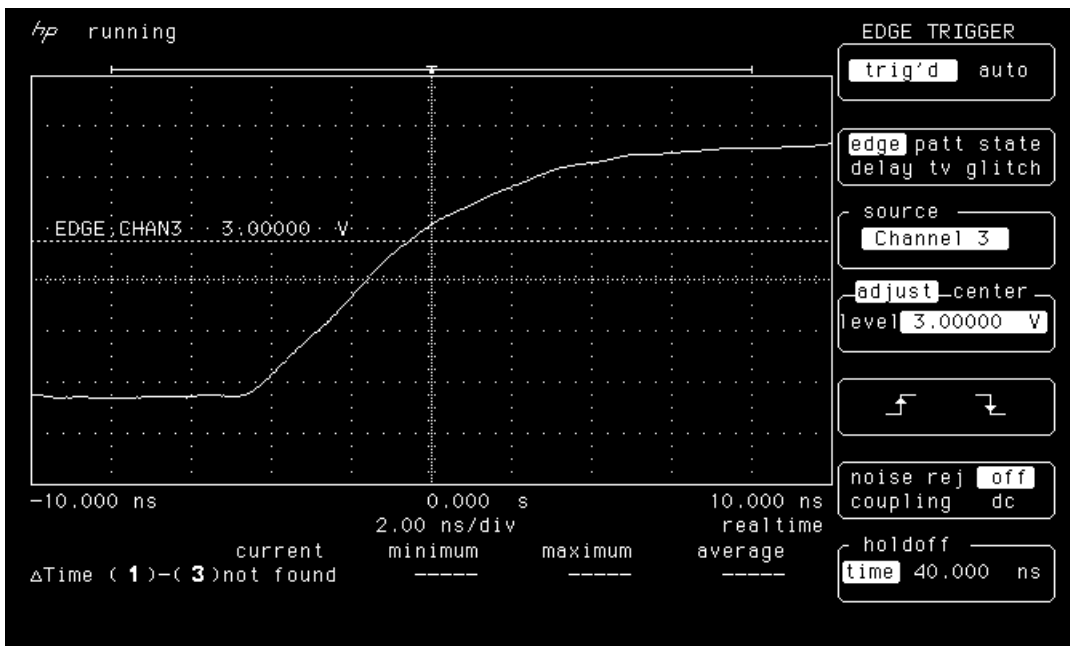


Figure 9c. Rising edge of LAN203 post-room-anneal.

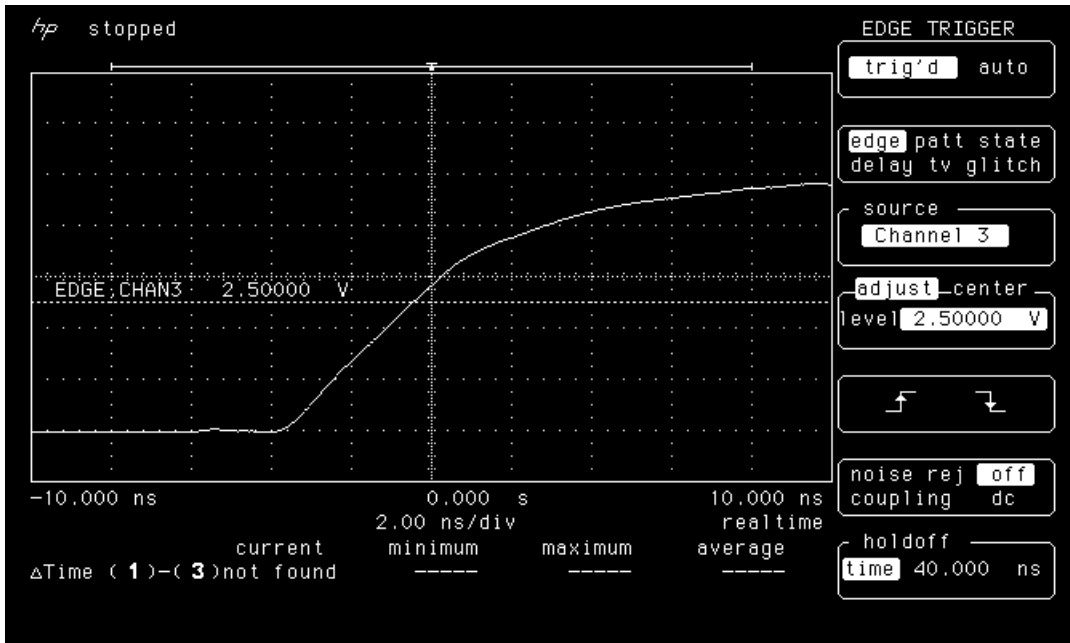


Figure 10a. Rising edge of LAN2004 pre-irradiation.

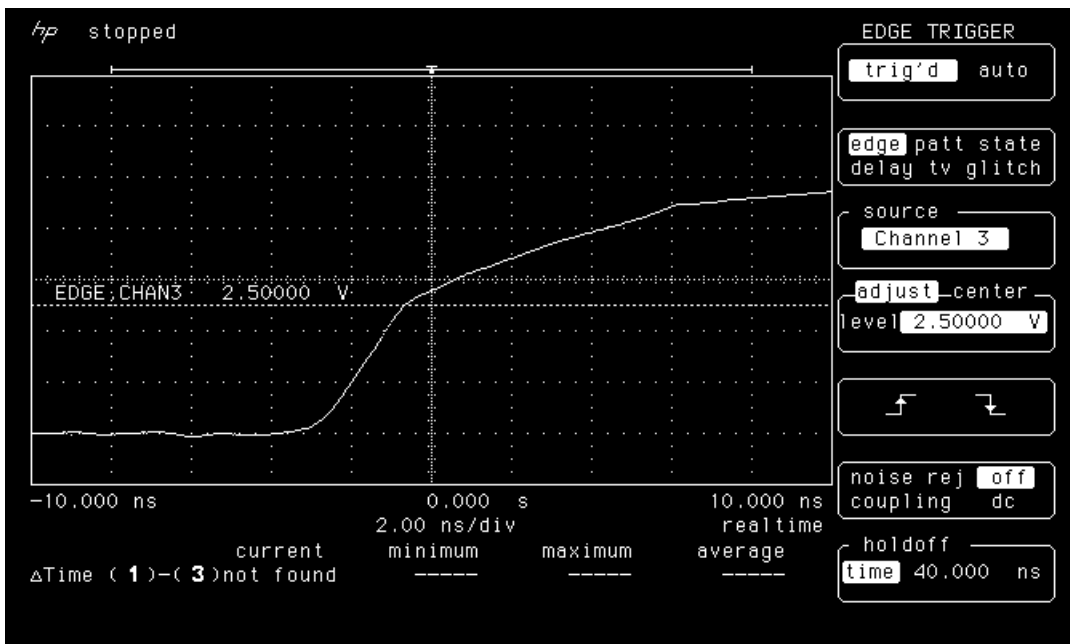


Figure 10b. Rising edge of LAN2004 post-irradiation.

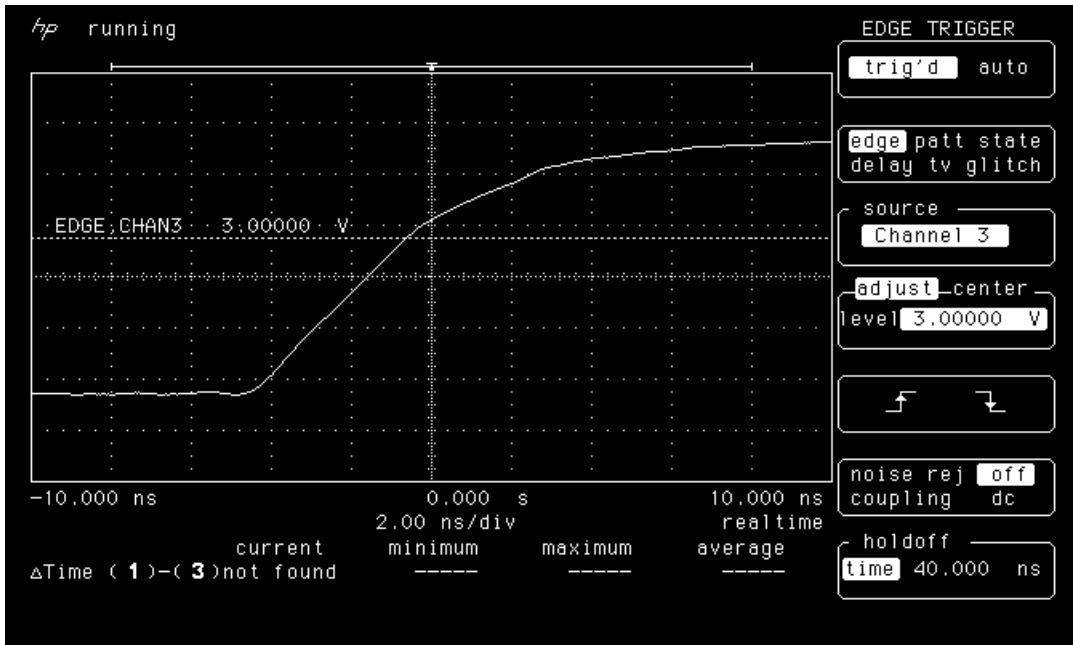


Figure 10c. Rising edge of LAN2004 post-anneal.

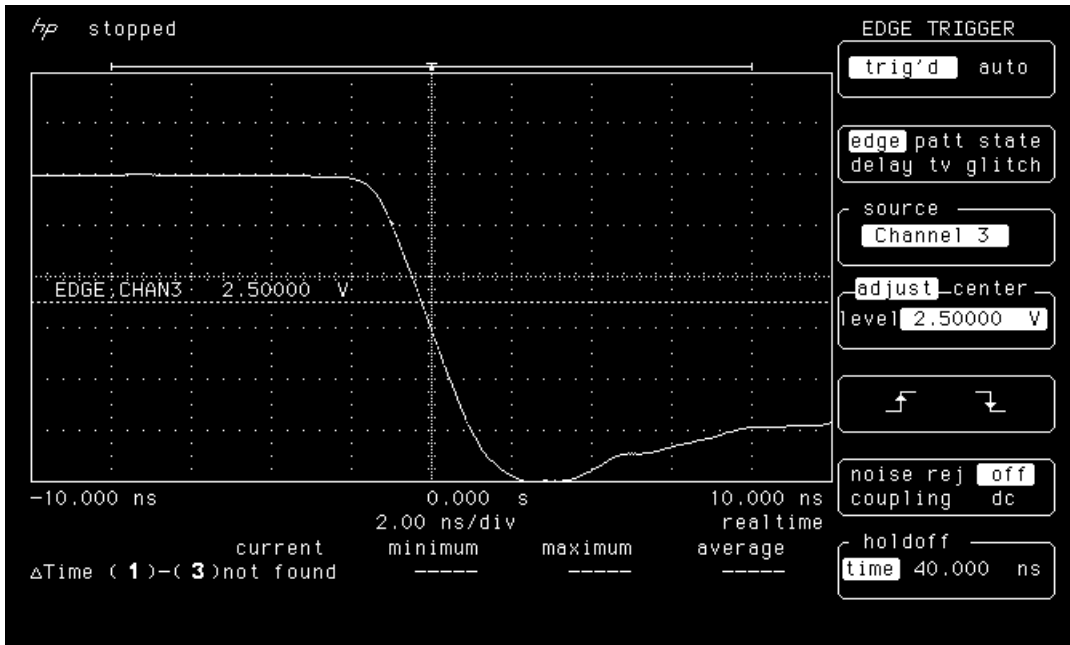


Figure 11a. Falling edge of LAN905 (control) measured with pre-irradiation DUTs.

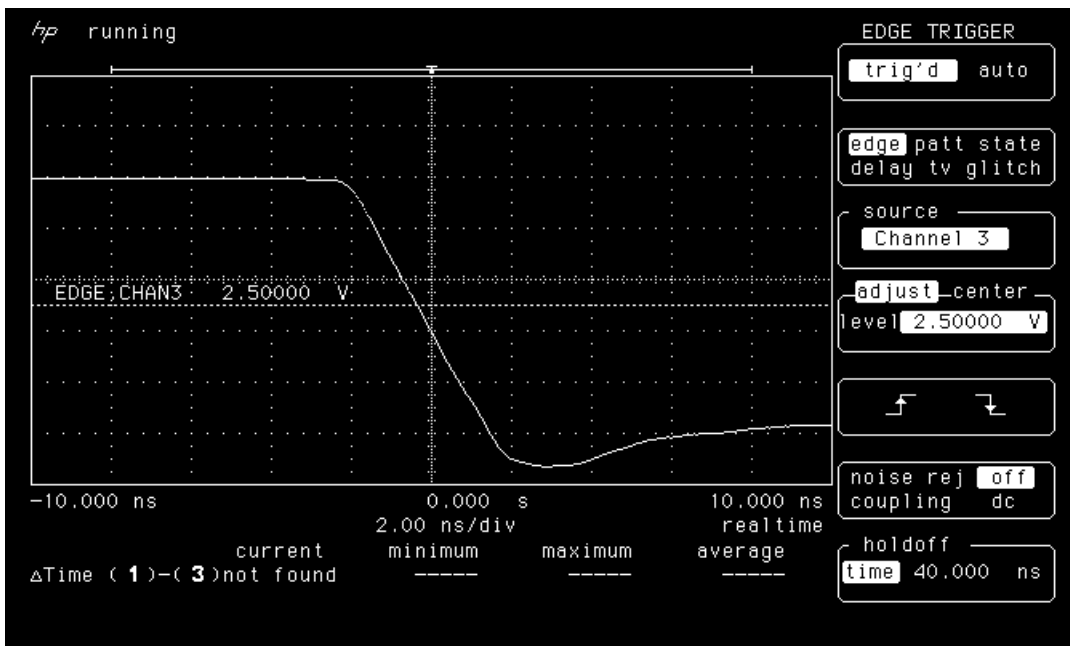


Figure 11b. Falling edge of LAN905 (control) measured with post-irradiation DUTs.



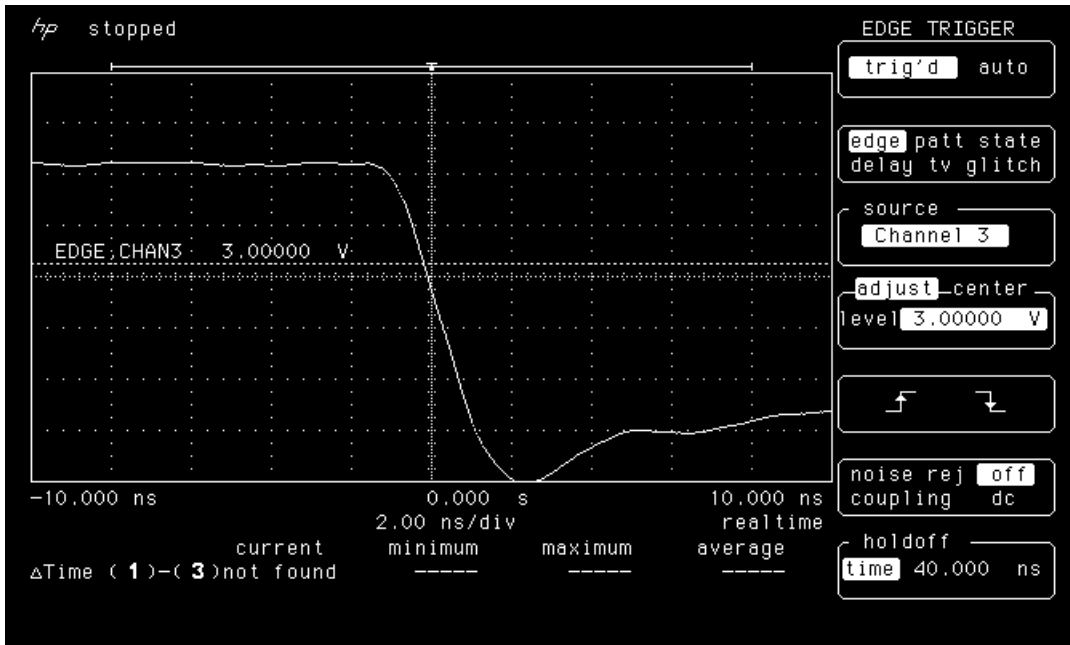


Figure 11c. Falling edge of LAN905 measured with post-anneal DUTs.

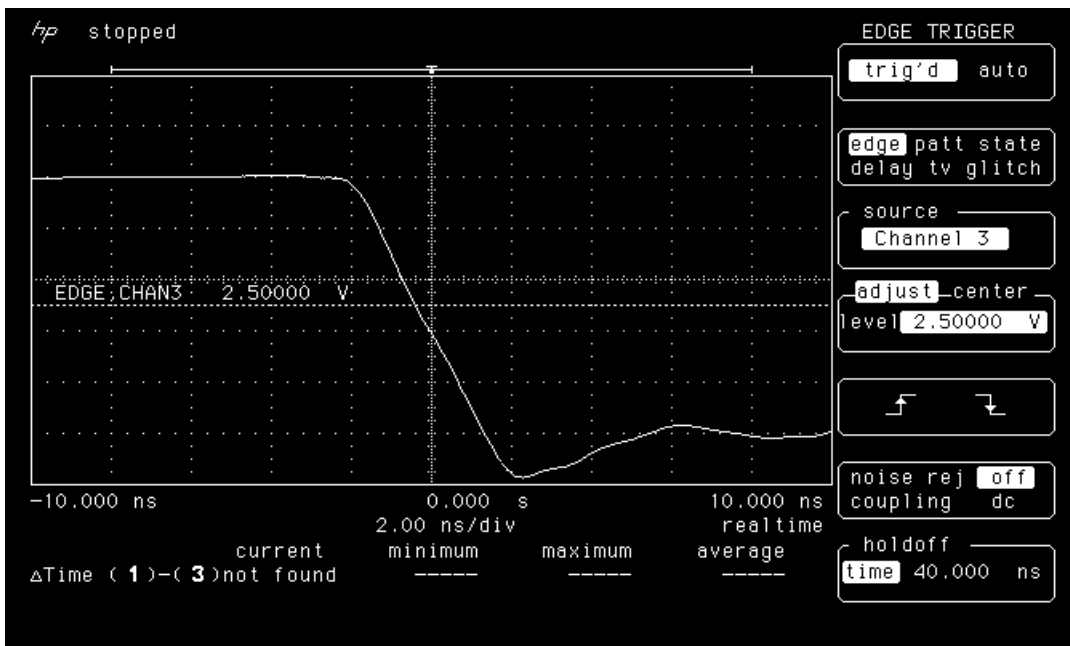


Figure 12a. Falling edge of LAN2001 pre-irradiation.

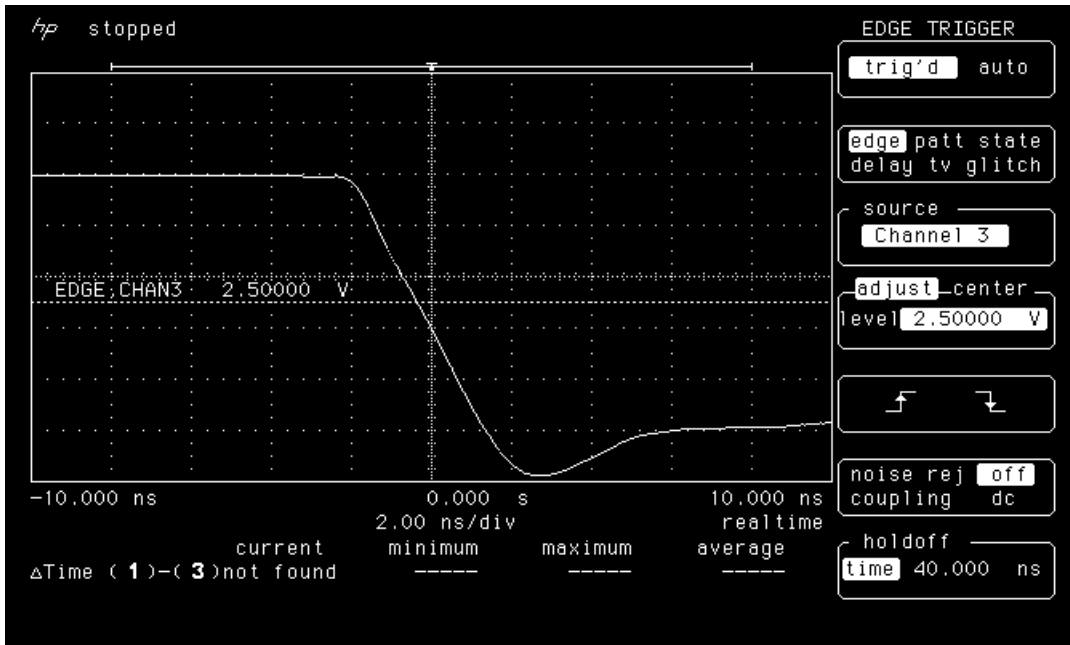


Figure 12b. Falling edge of LAN2001 post-irradiation

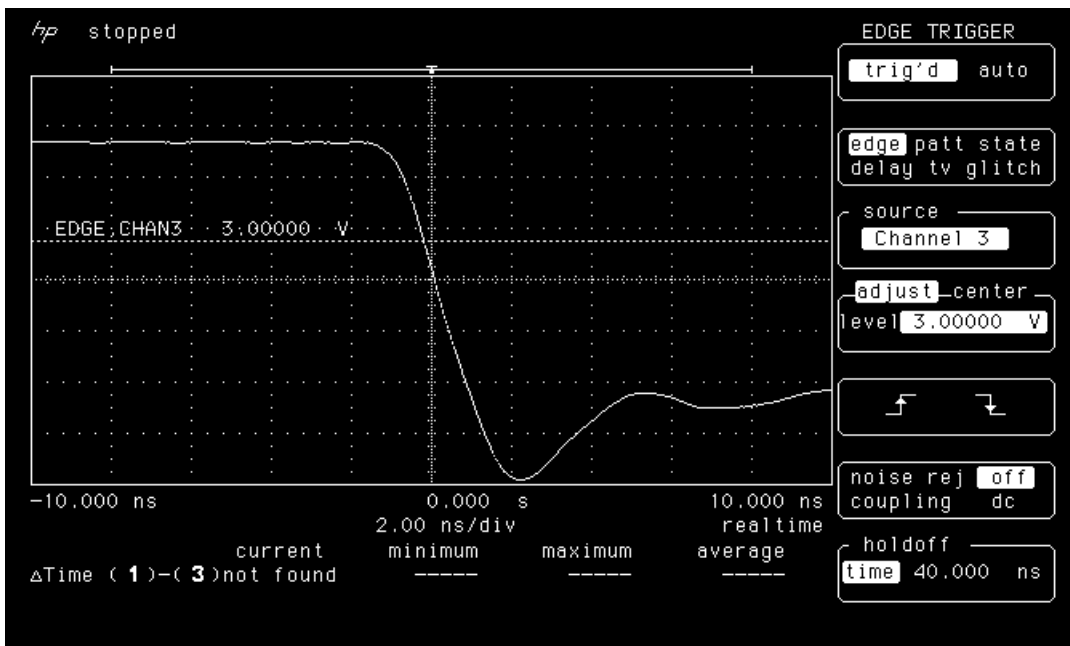


Figure 12c. Falling edge of LAN2001 post-anneal.

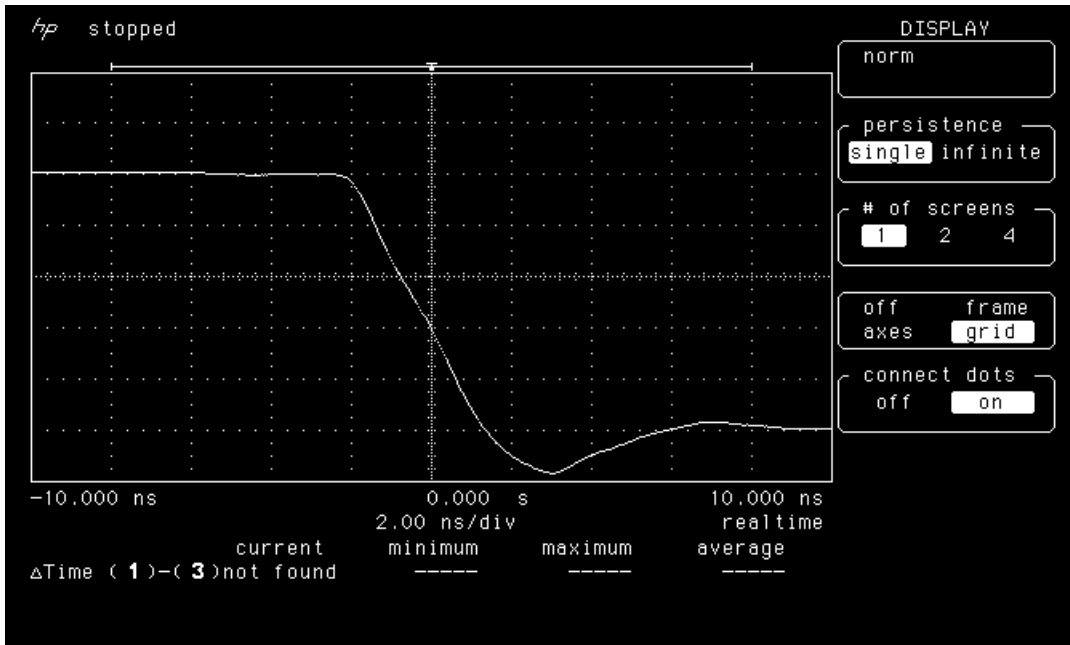


Figure 13a. Falling edge of LAN2002 pre-irradiation.

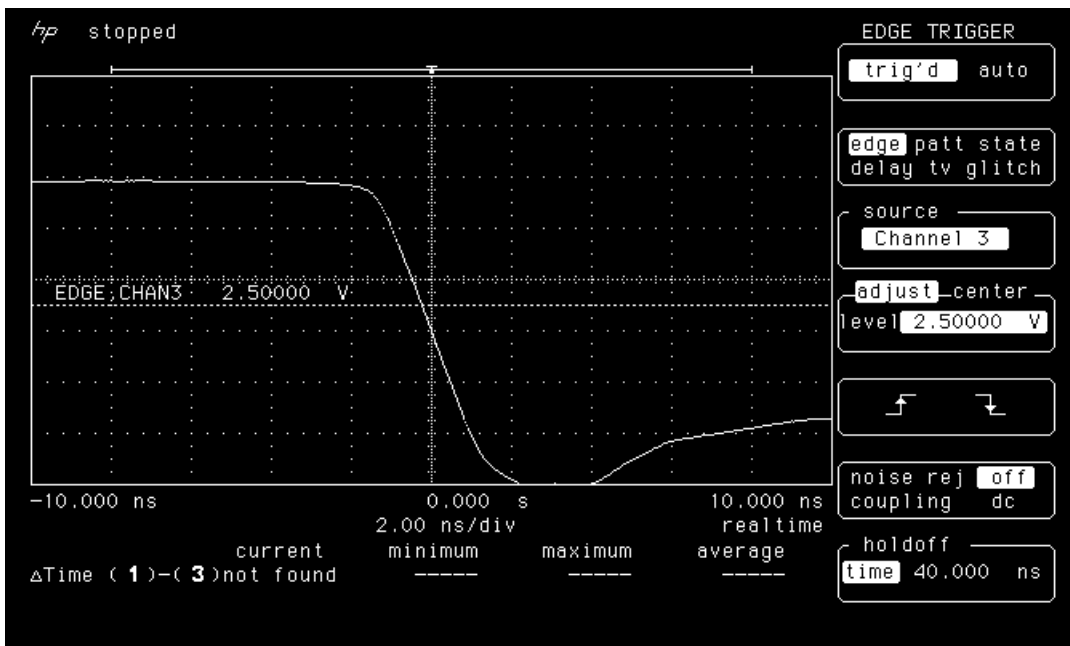


Figure 13b. Falling edge of LAN2002 post-irradiation

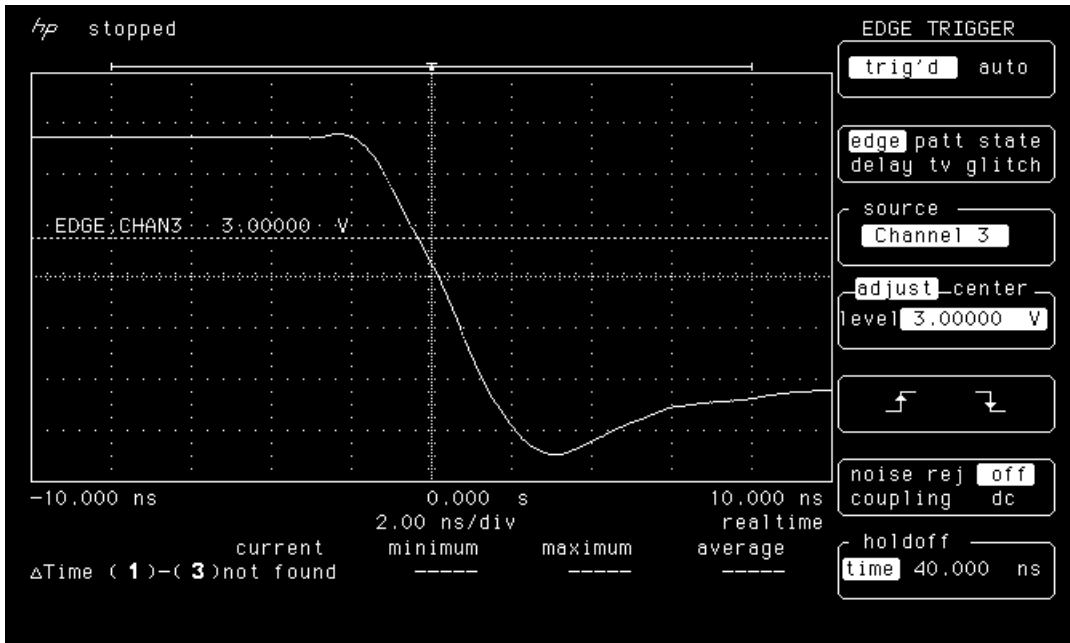


Figure 13c. Falling edge of LAN2002 post-anneal.

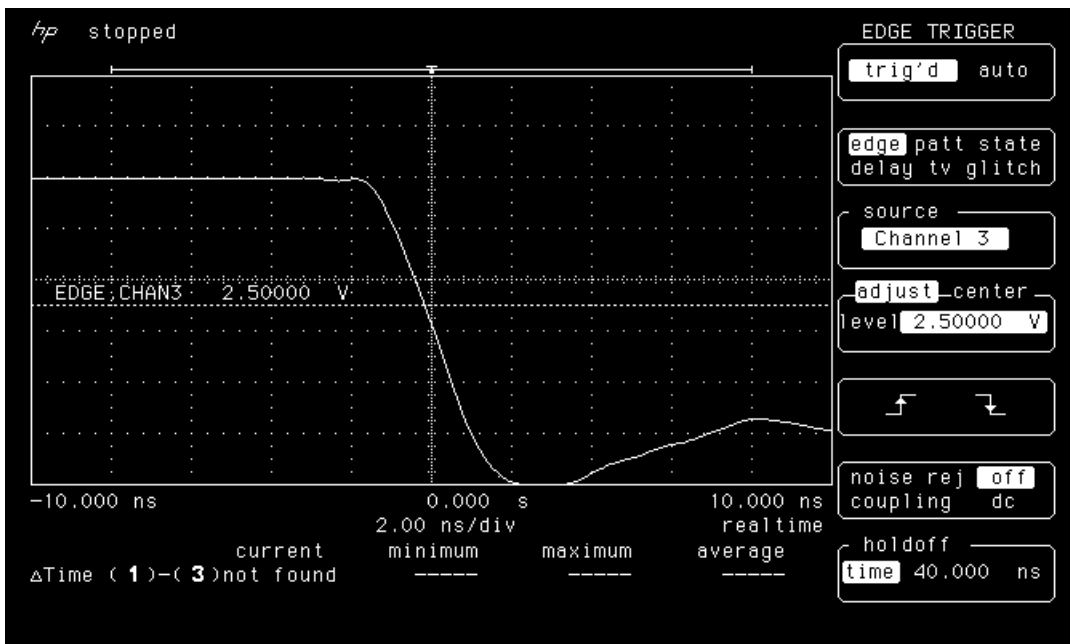


Figure 14a. Falling edge of LAN2003 pre-irradiation.

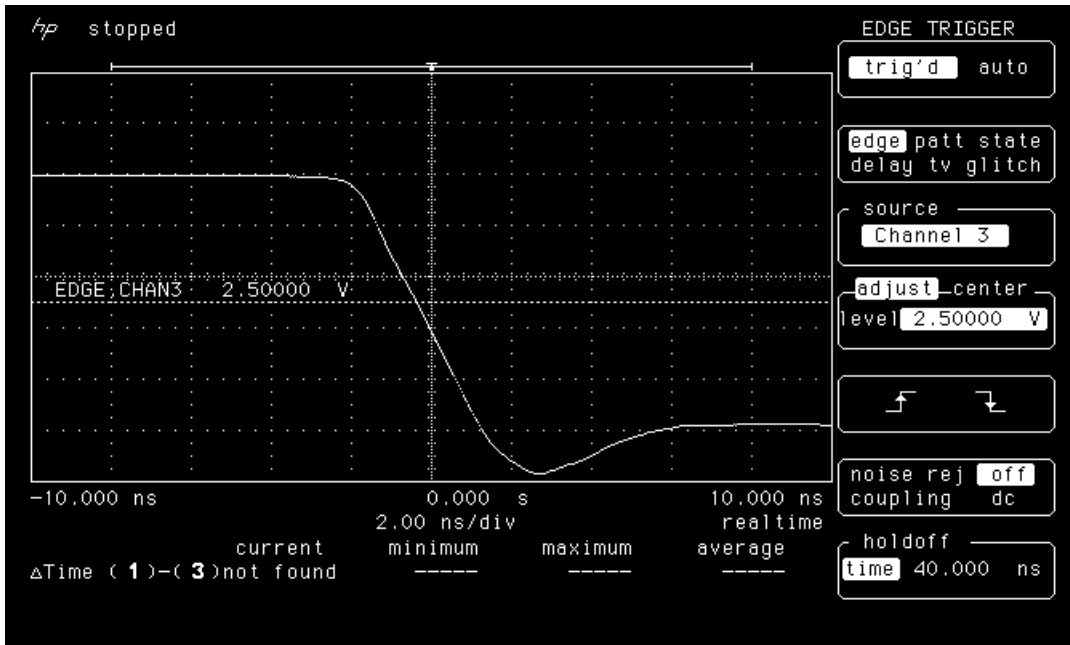


Figure 14b. Falling edge of LAN2003 post-irradiation.

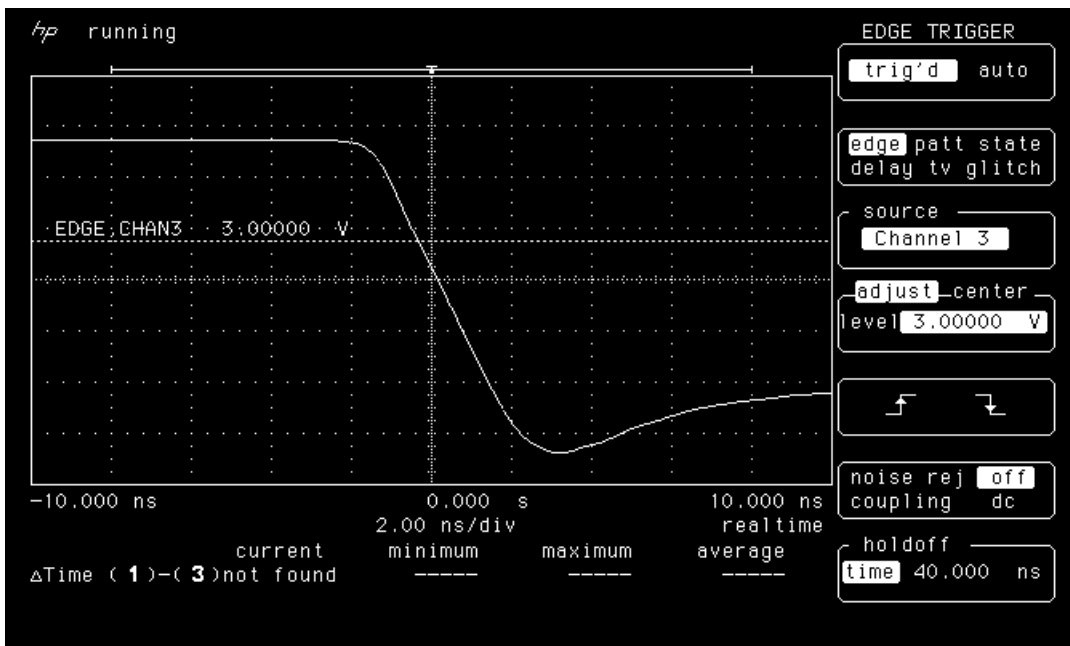


Figure 14c. Falling edge of LAN2003 post-anneal.

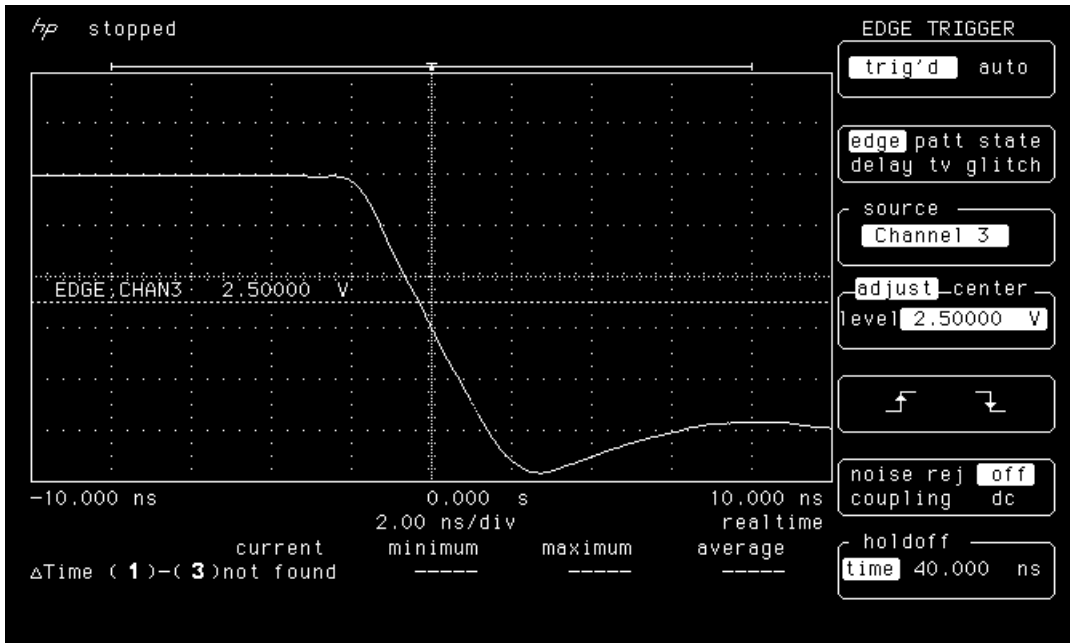


Figure 15a. Falling edge of LAN2004 pre-irradiation.

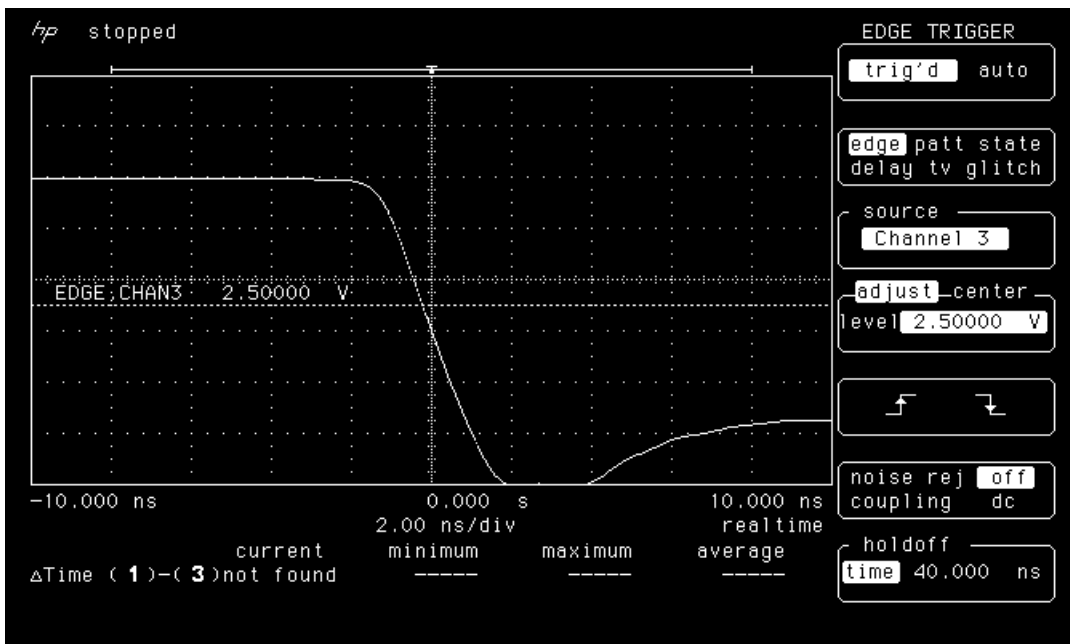


Figure 15b. Falling edge of LAN2003 post-irradiation.

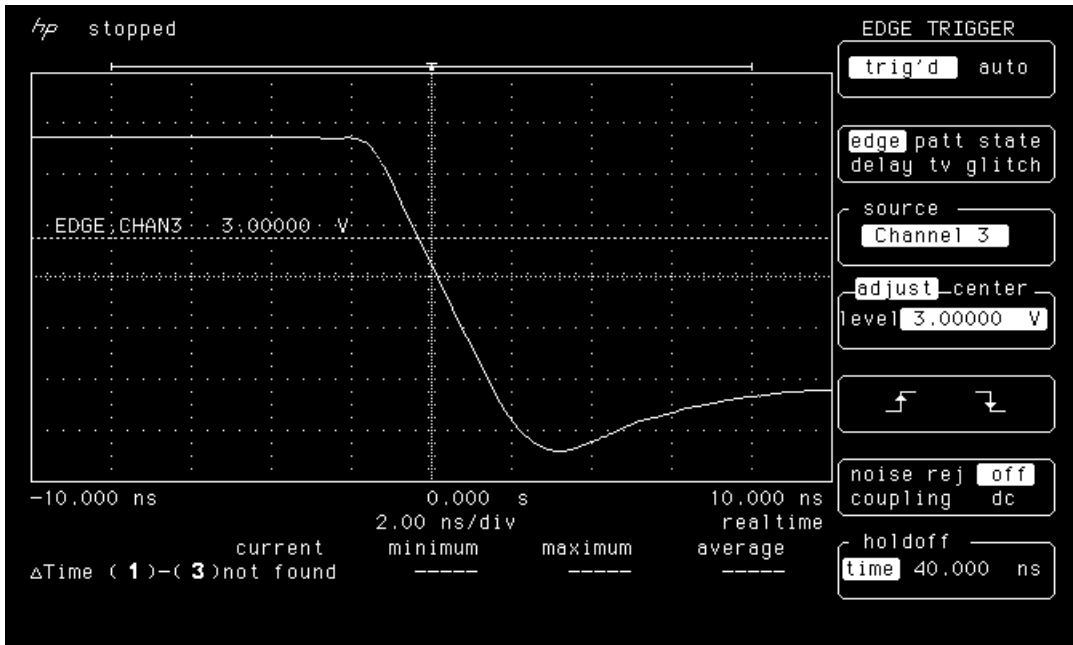


Figure 15c. Falling edge of LAN2003 post-anneal.

### **3.7 STARTUP TRANSIENT**

In each measurement, the power supply ( $V_{CC}$ ) rising time was set at 1.2ms. The board housing the DUT has minimum capacitance so that the transient current is all coming from the DUT. Figure 16-20 shows the oscilloscope picture of the startup transient of the DUTs. In each picture, there is a curve showing  $V_{CC}$  ramping from GND to 5V, and another curve showing  $I_{CC}$  which has a transient pulse at  $V_{CC}$  close to 3V. The scale is 1V per division for  $V_{CC}$  and 100mA per division for  $I_{CC}$ . The transient pulse of  $I_{CC}$  is approximately 100mA peak and less than 100 $\mu$ s width. From these pictures, it can be concluded that the irradiation (within 20krad(Si) total dose) does not increase the transient pulse.



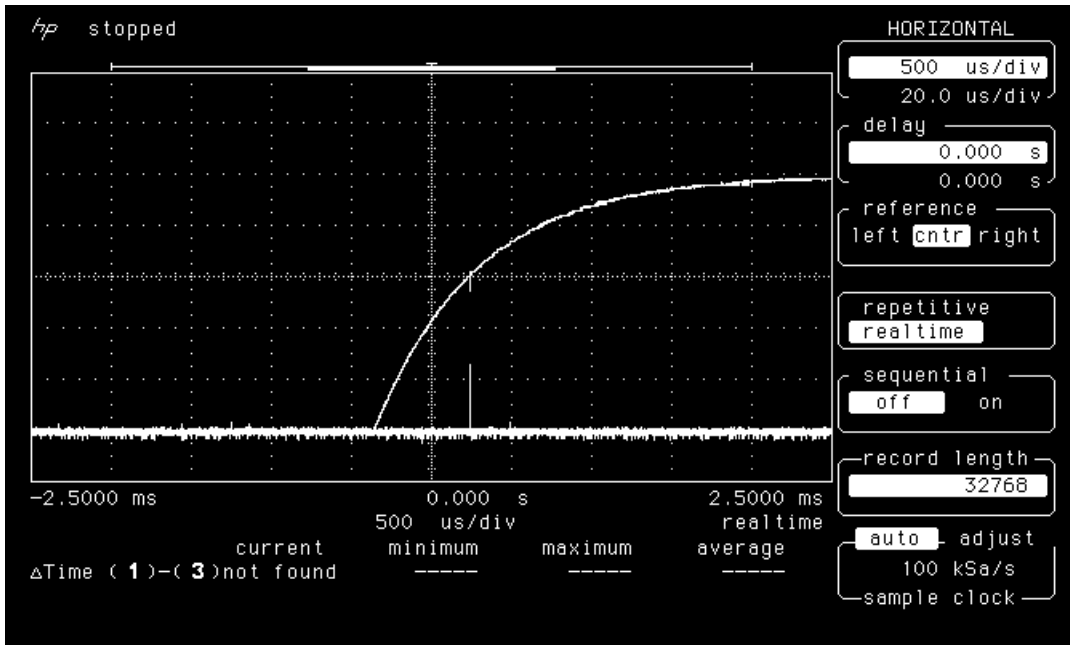


Figure 16a. Startup transient of LAN905 (control) measured with pre-irradiation DUTs.

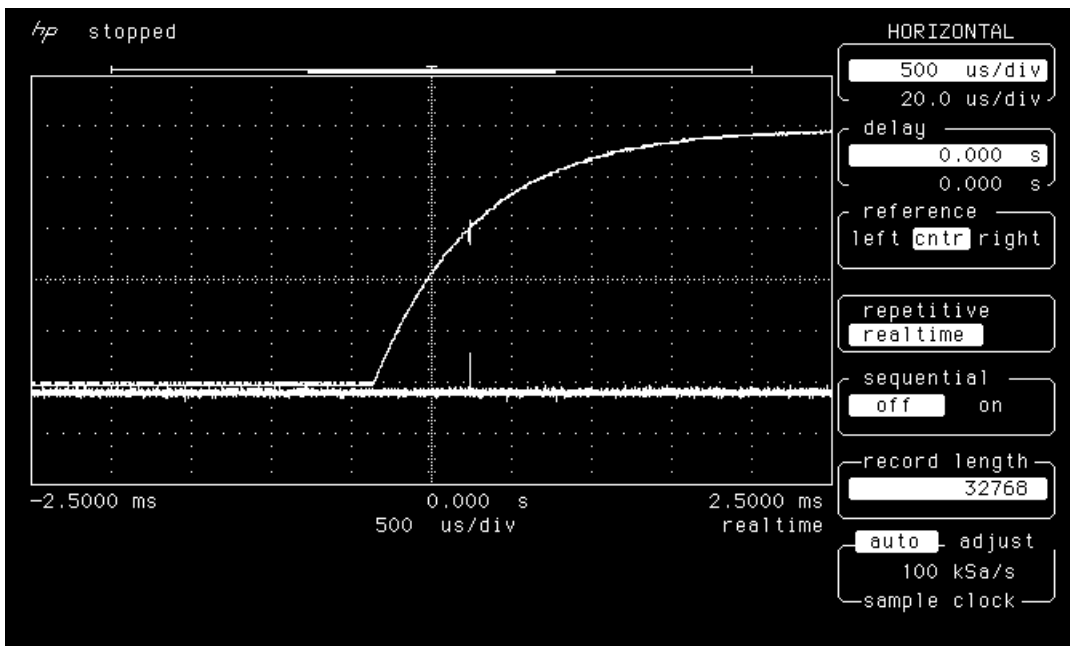


Figure 16b. Startup transient of LAN905 (control) measured with post-anneal DUTs

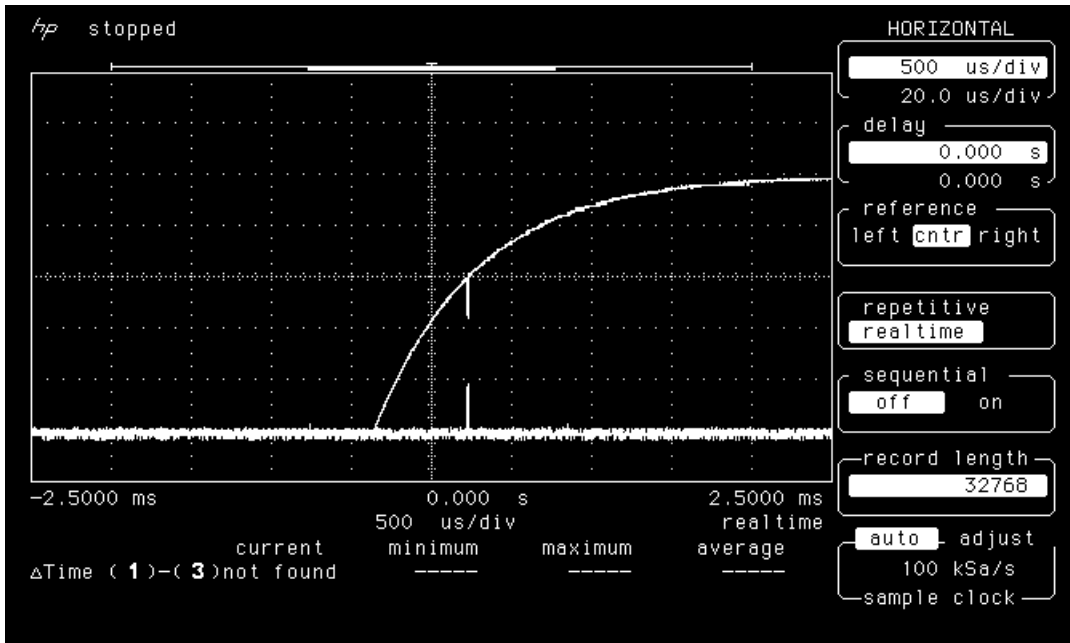


Figure 17a. Startup transient of LAN2001 pre-irradiation.

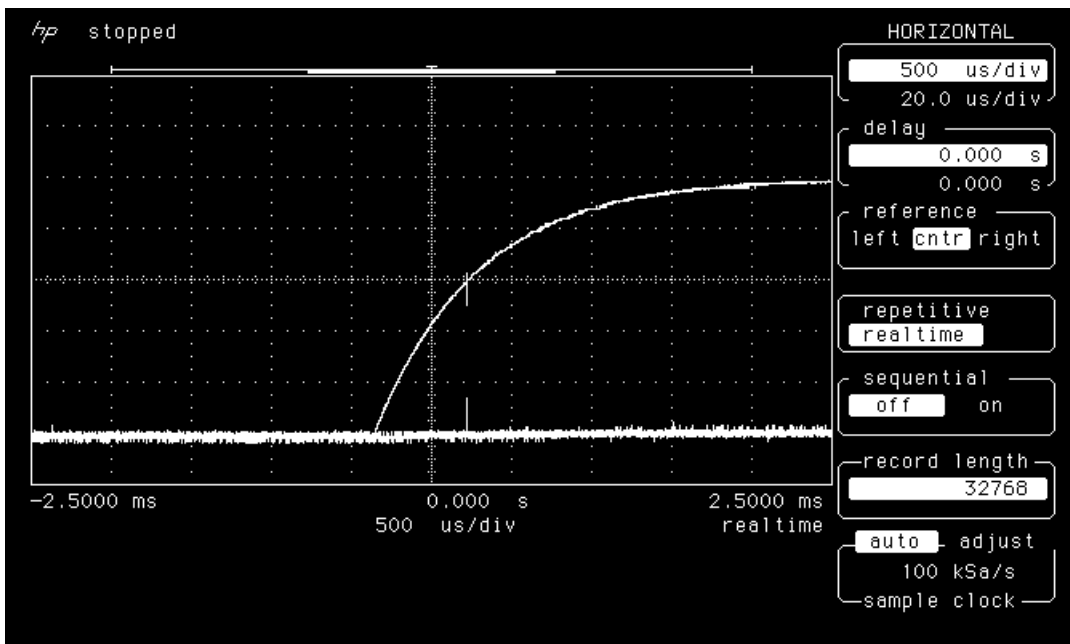


Figure 17b. Startup transient of LAN2001 post-irradiation.

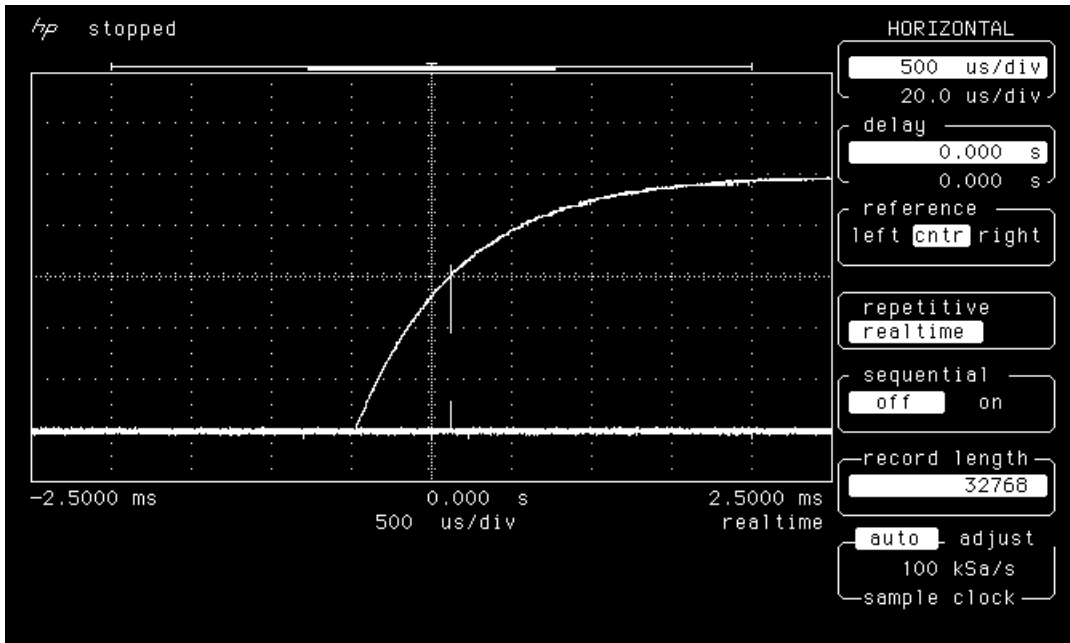


Figure 18a. Startup transient of LAN2002 pre-irradiation.

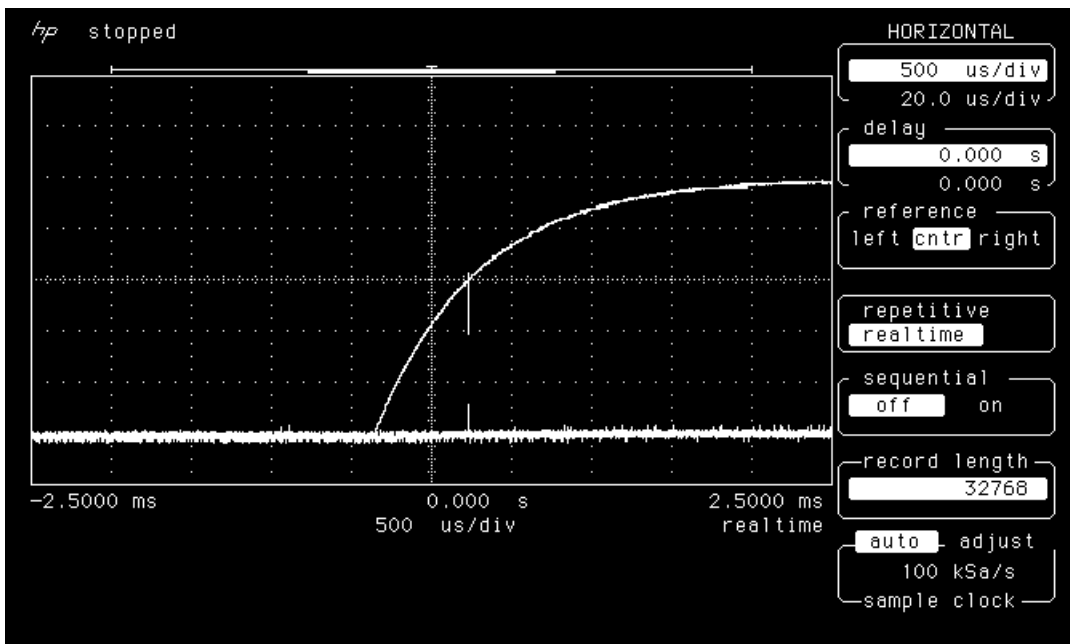


Figure 18b. Startup transient of LAN2002 post-irradiation

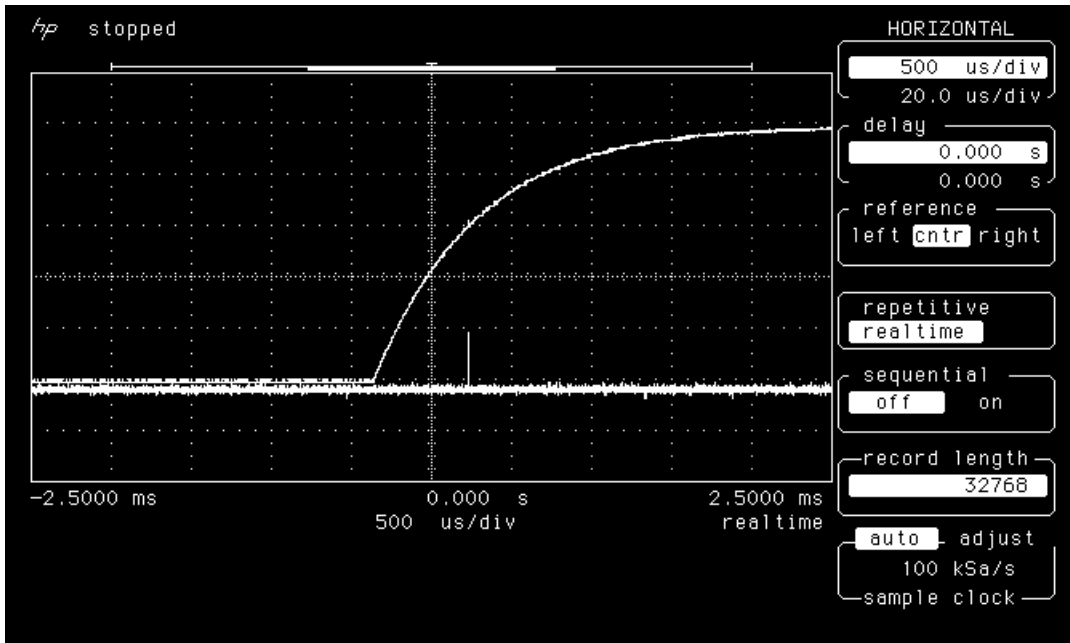


Figure 18c. Startup transient of LAN2002 post-anneal.

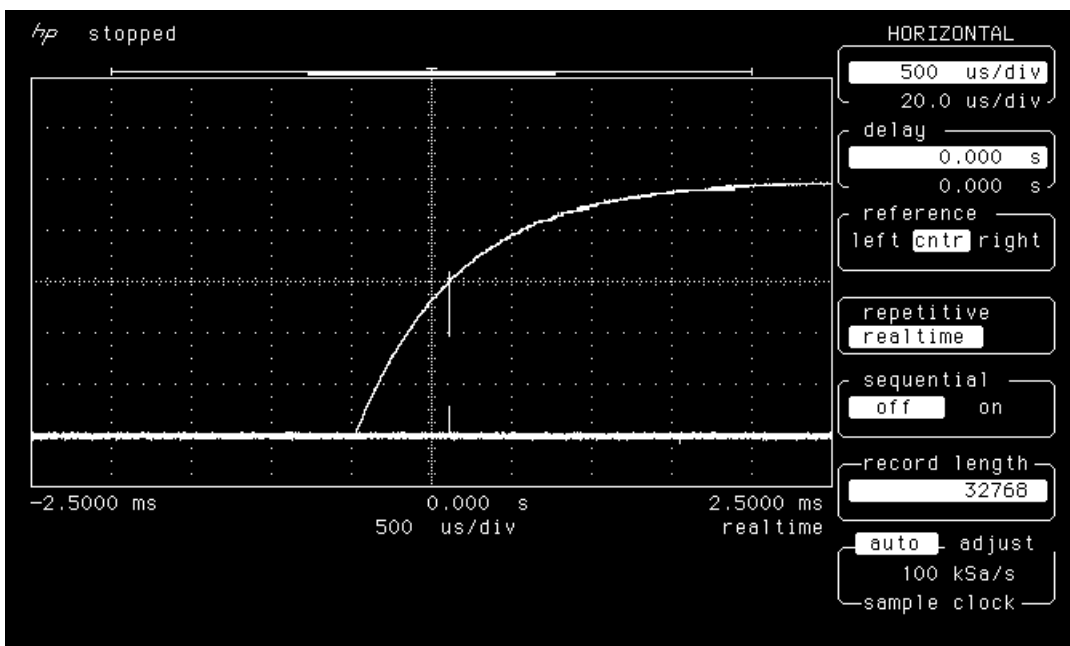


Figure 19a. Startup transient of LAN2003 pre-irradiation.

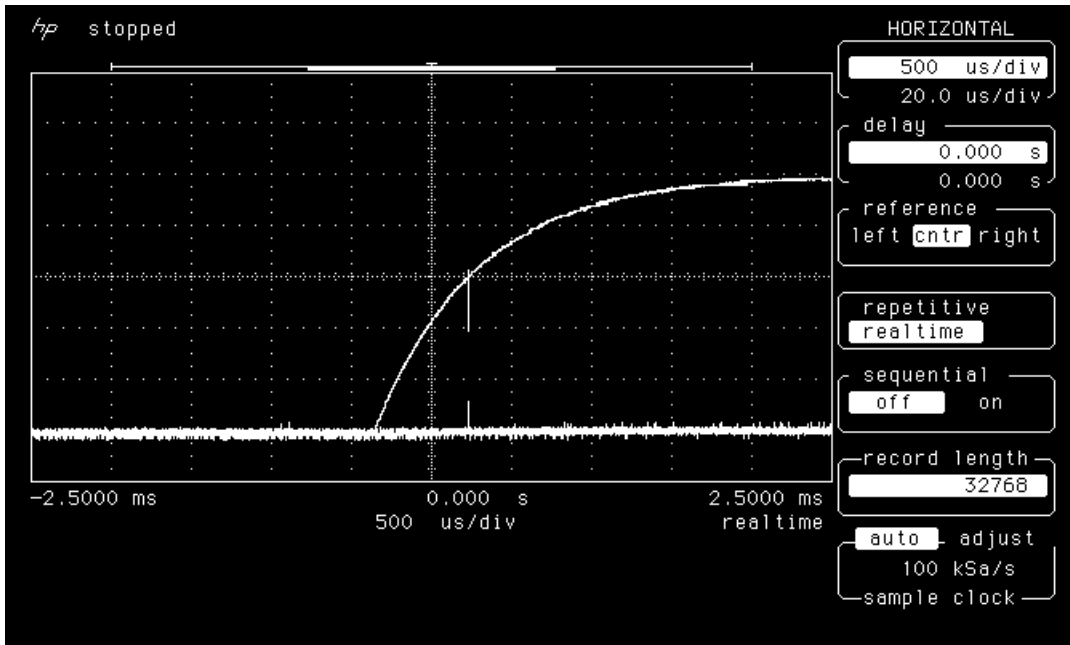


Figure 19b. Startup transient of LAN2003 post-irradiation.

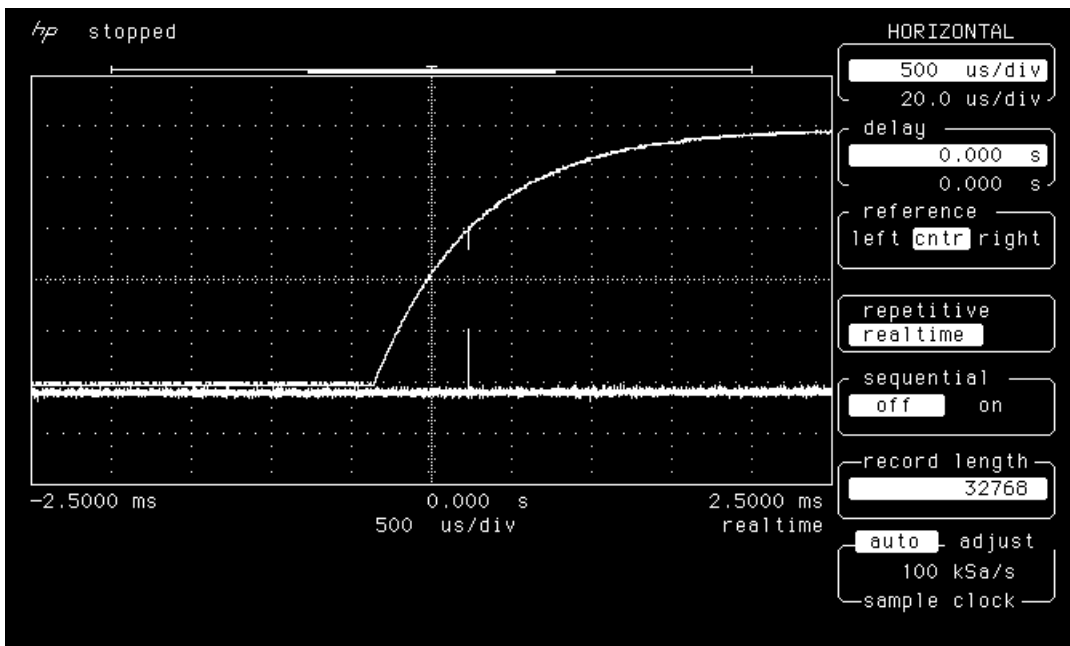


Figure 19c. Startup transient of LAN2003 post-anneal.

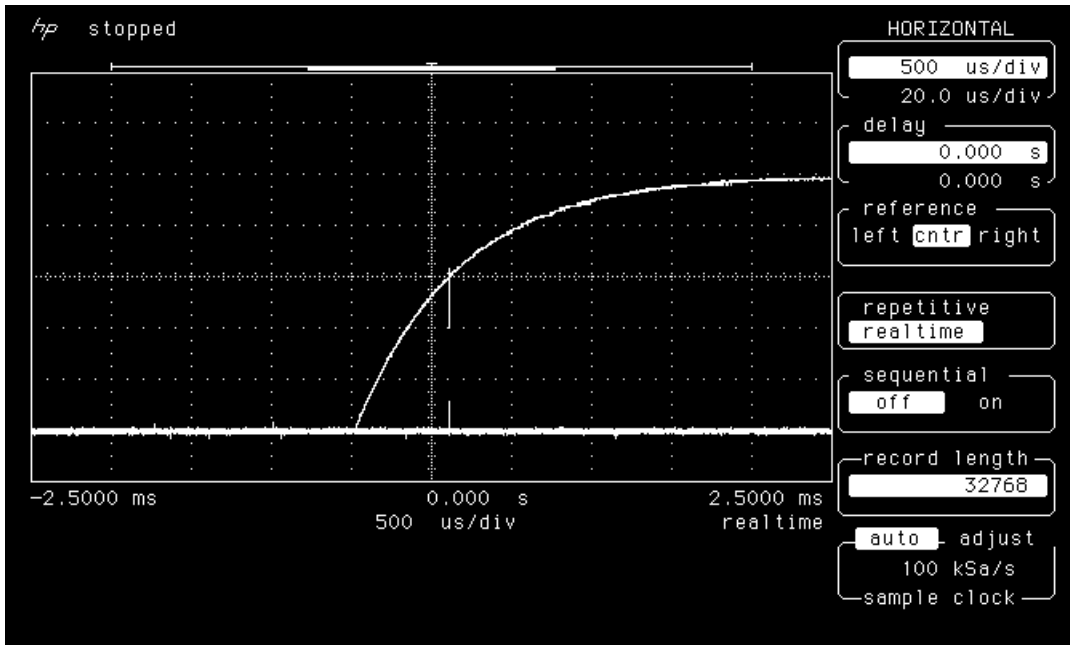


Figure 20a. Startup transient of LAN2004 pre-irradiation.

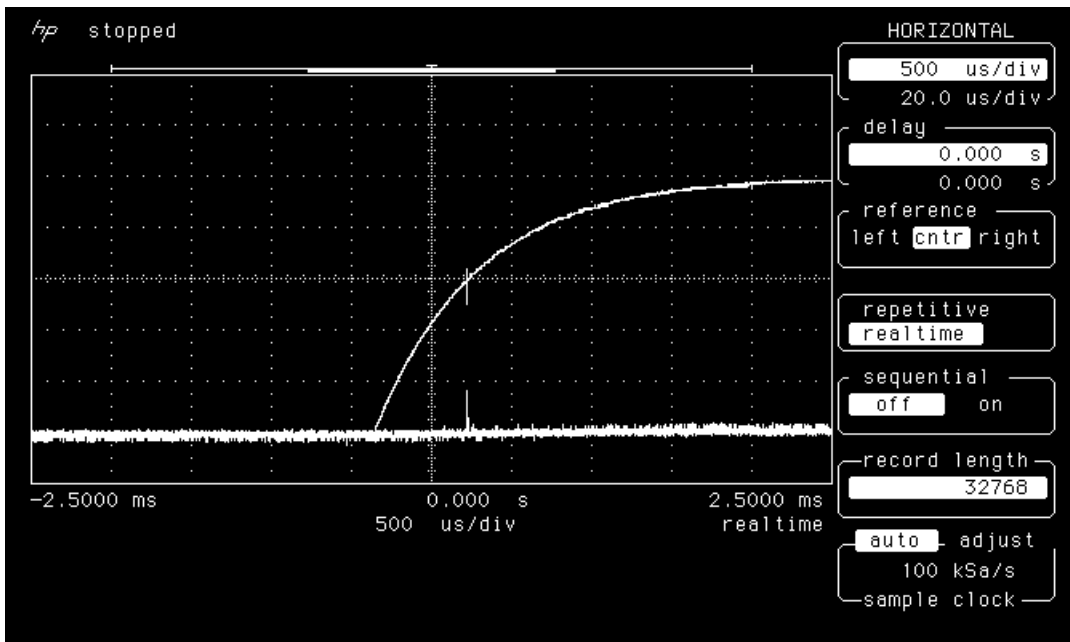


Figure 20b. Startup transient of LAN2004 post-irradiation.

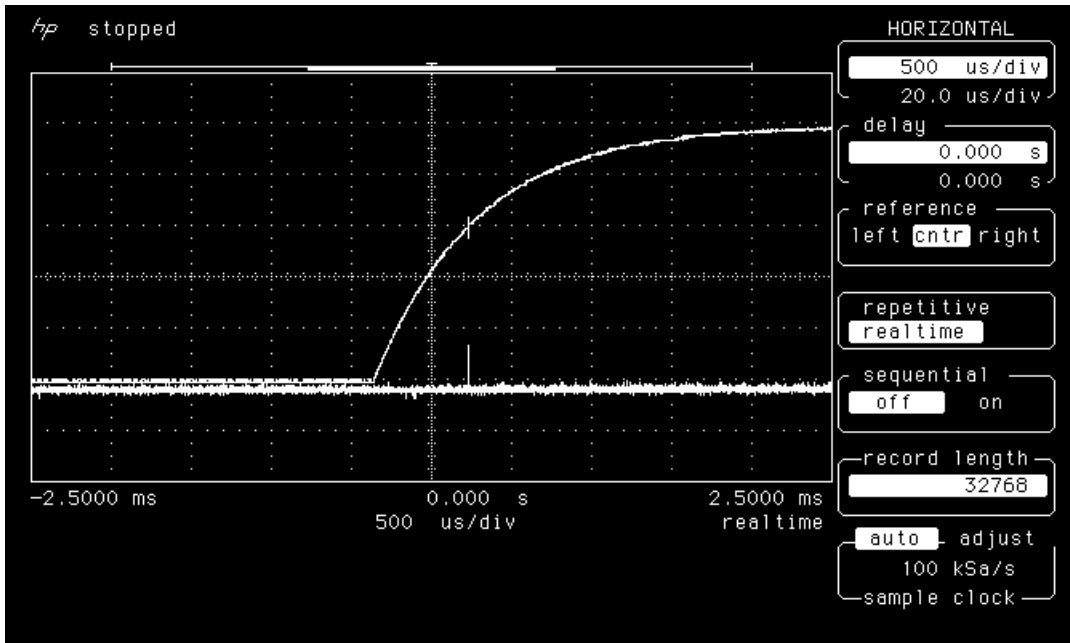


Figure 20c. Startup transient of LAN2004 post-anneal.